

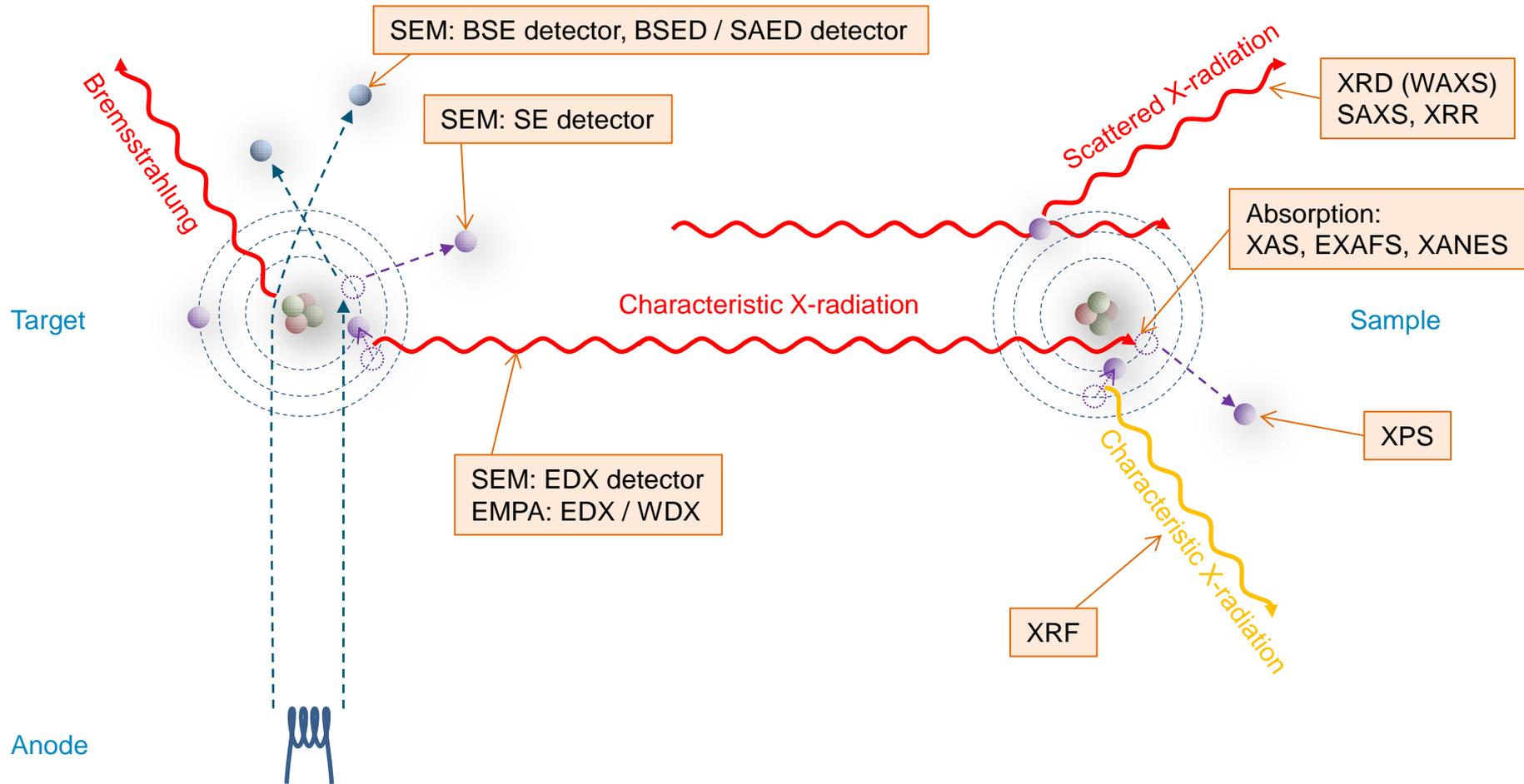
# Lesson 2

## Diffractometers

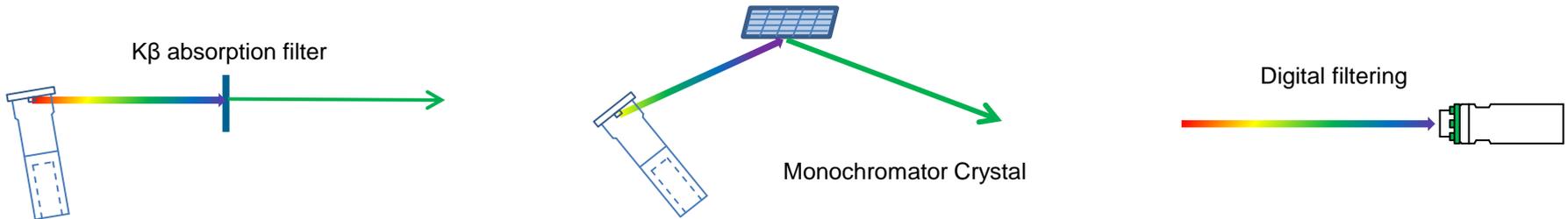
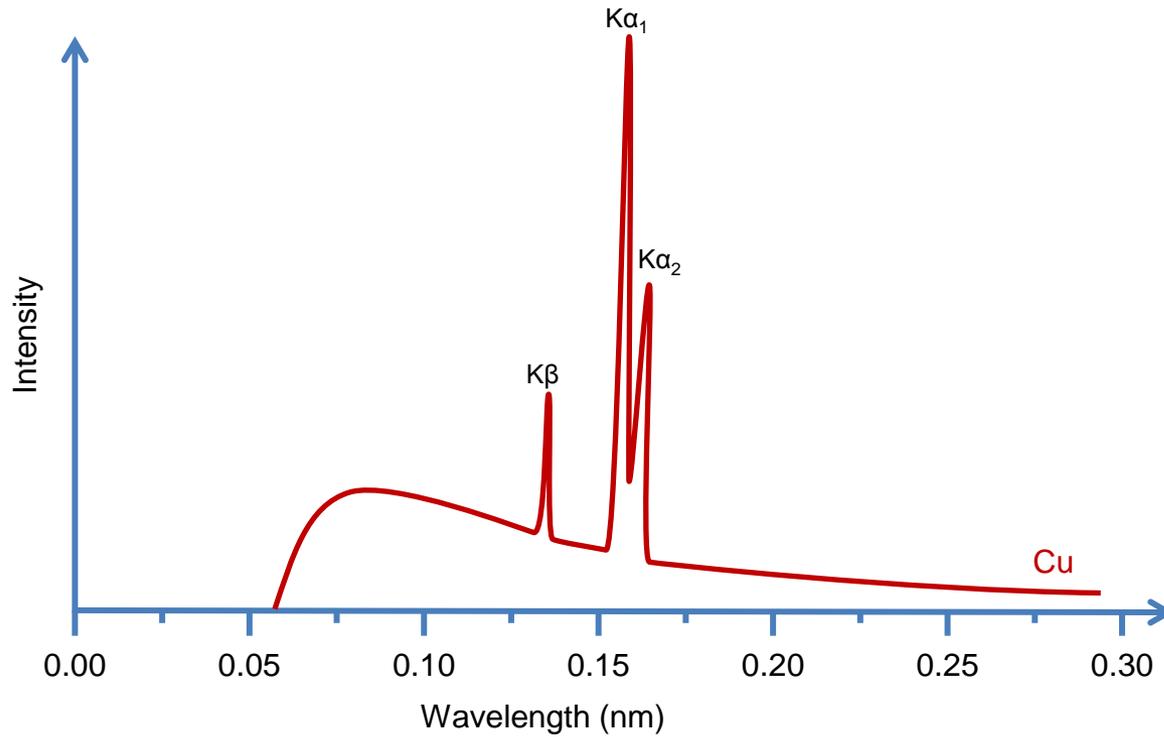
Nicola Döbelin  
RMS Foundation, Bettlach, Switzerland



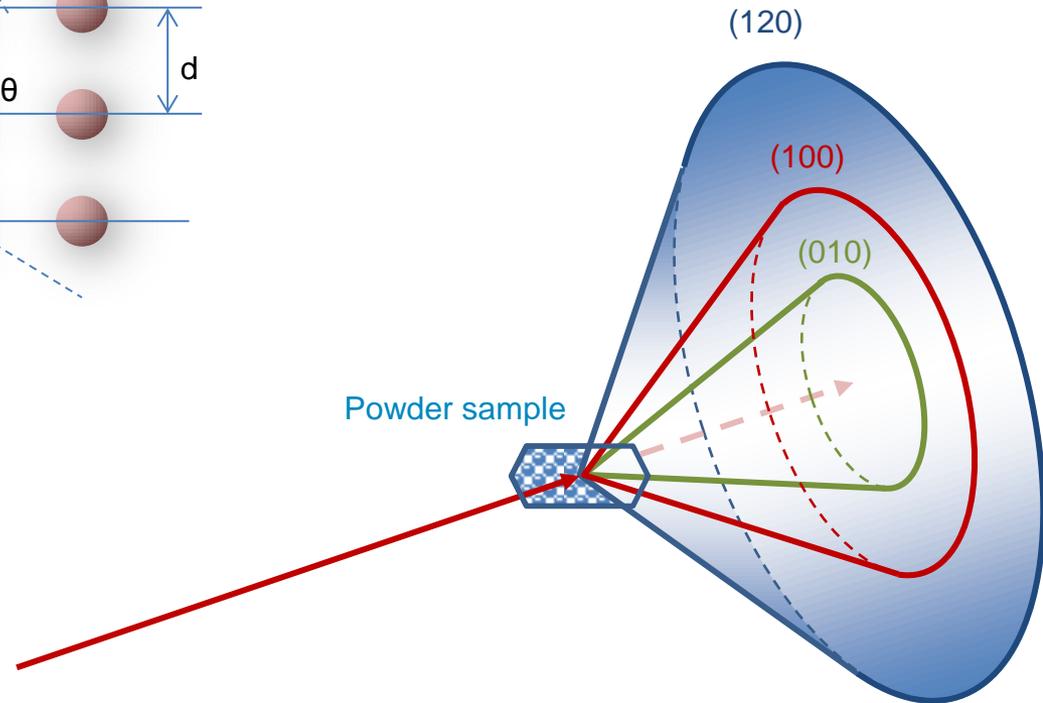
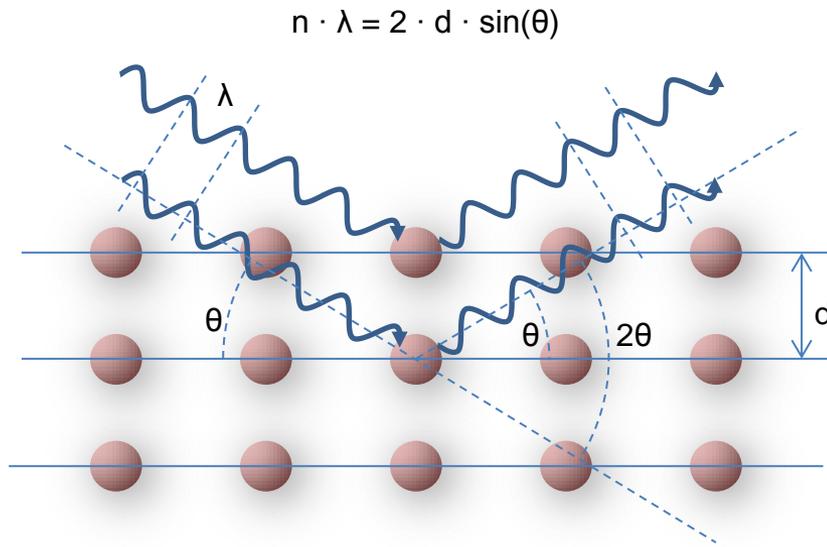
# Repetition: Generation of X-rays / Diffraction



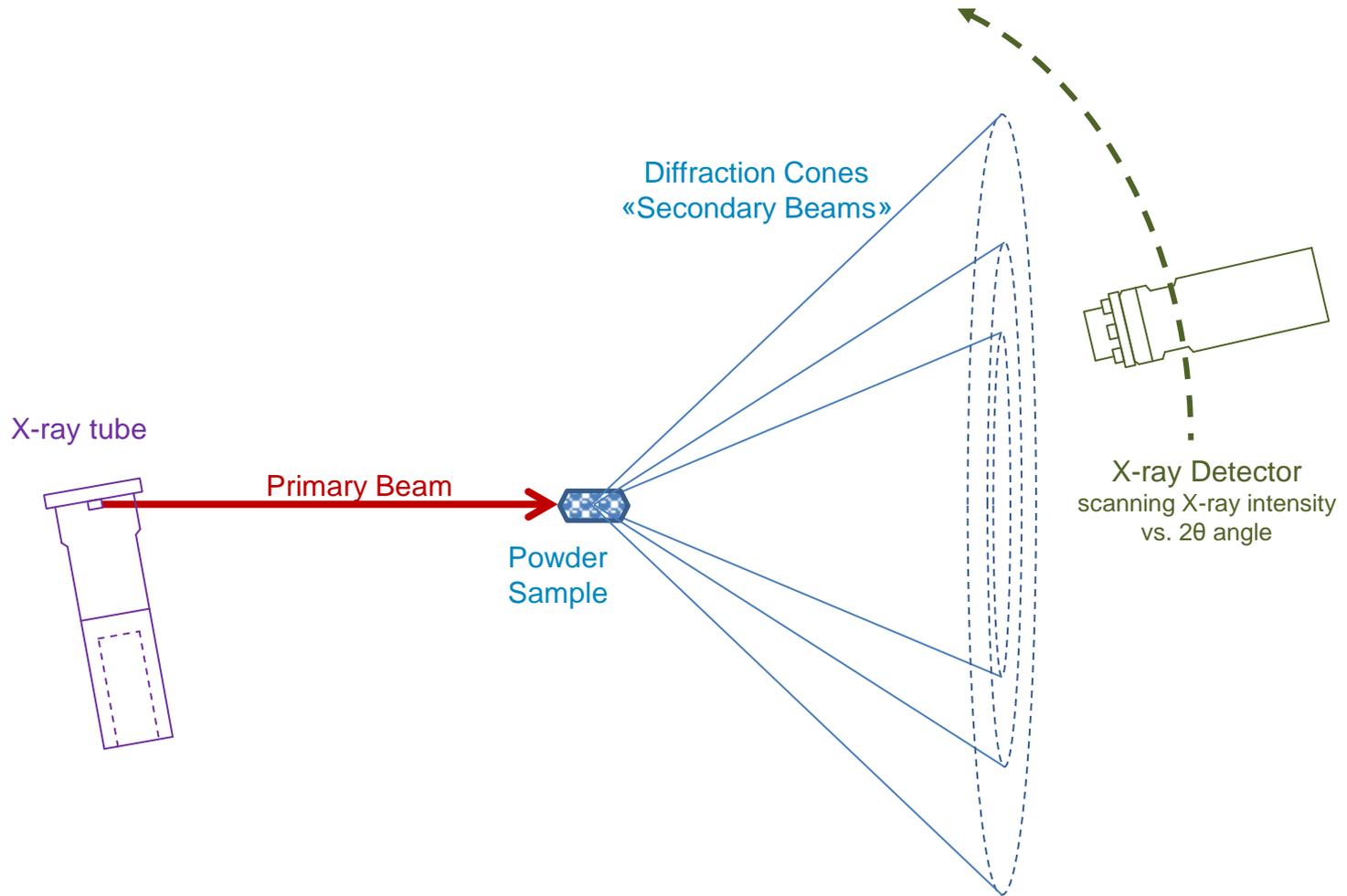
# Repetition: Generation of X-rays



# Repetition: Powder Diffraction

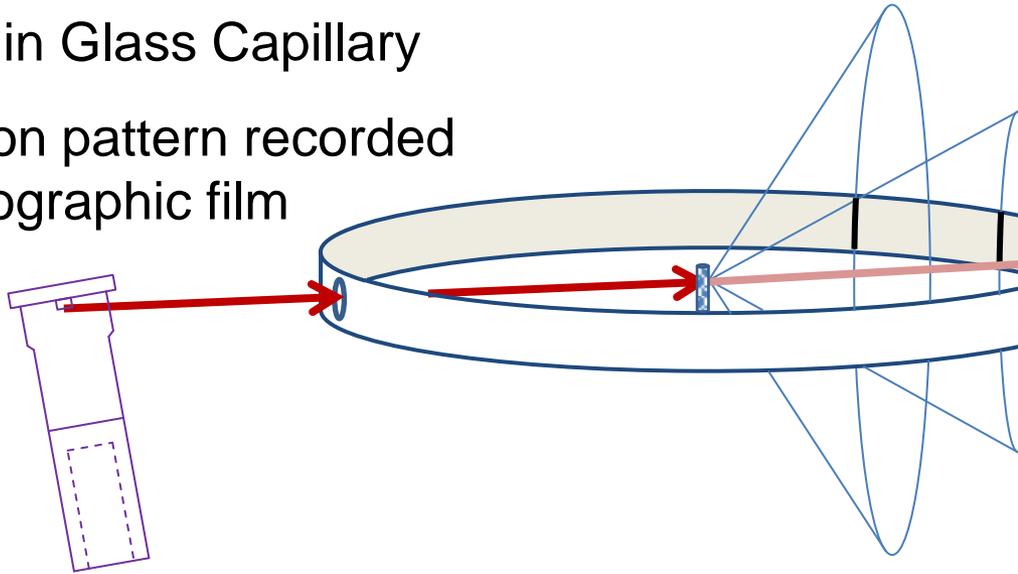


# Repetition: Powder Diffractometer

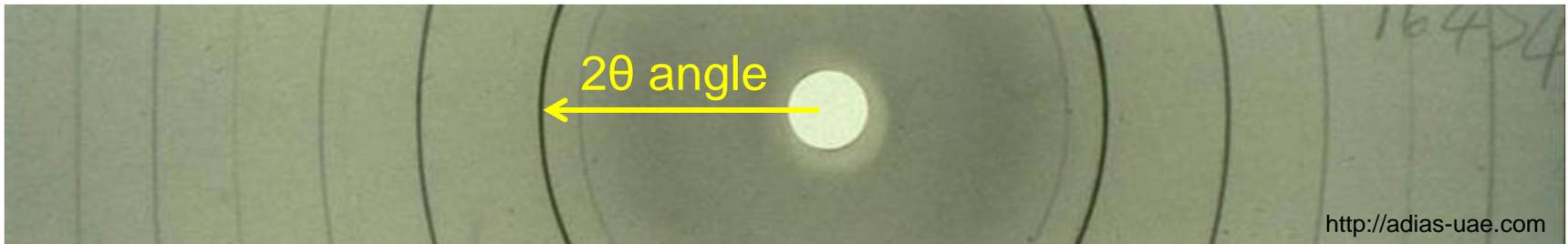


# Analogue Cameras

Debye-Scherrer Camera:  
Powder in Glass Capillary  
Diffraction pattern recorded  
on photographic film

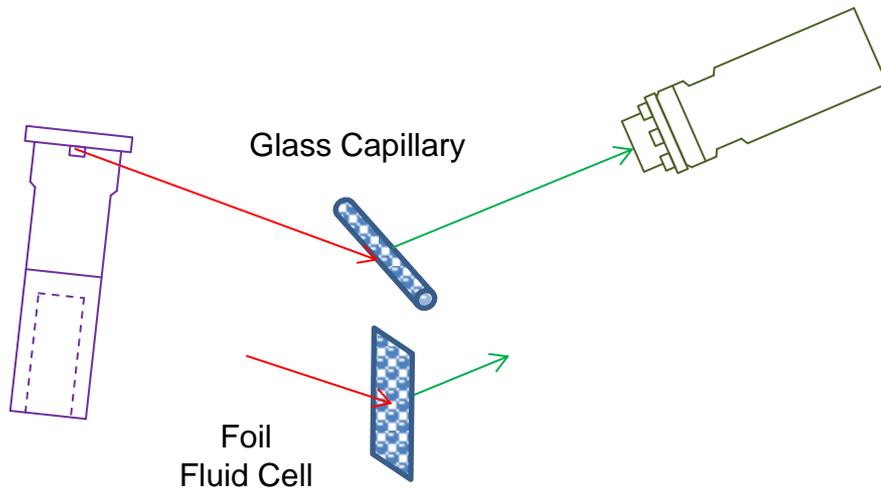


Various alternative setups:  
Gandolfi ...  
Guinier ...  
Straumanis ...  
Bradley ...  
Seemann-Bohlin ...  
...Camera



# Digital Diffractometers

## Transmission Geometry

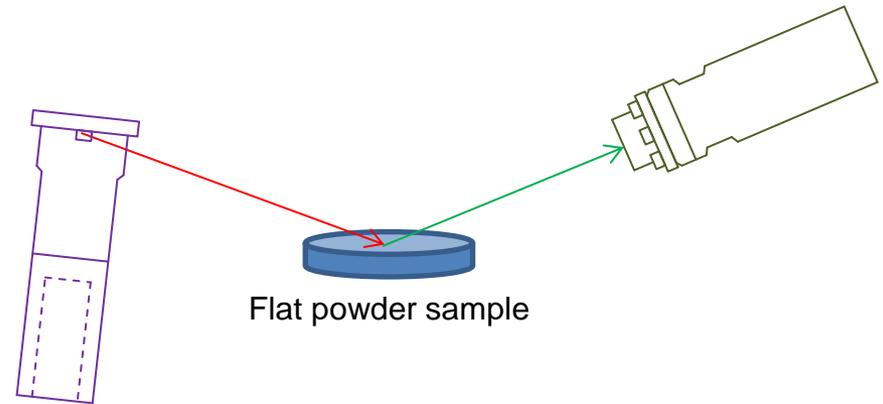


Capillaries are ideal for:

- Light atoms (Polymers, Pharmaceuticals)
- Small amounts
- Hazardous materials
- Air-sensitive materials

Use characteristic radiation with low absorption coefficient

## Reflective Geometry



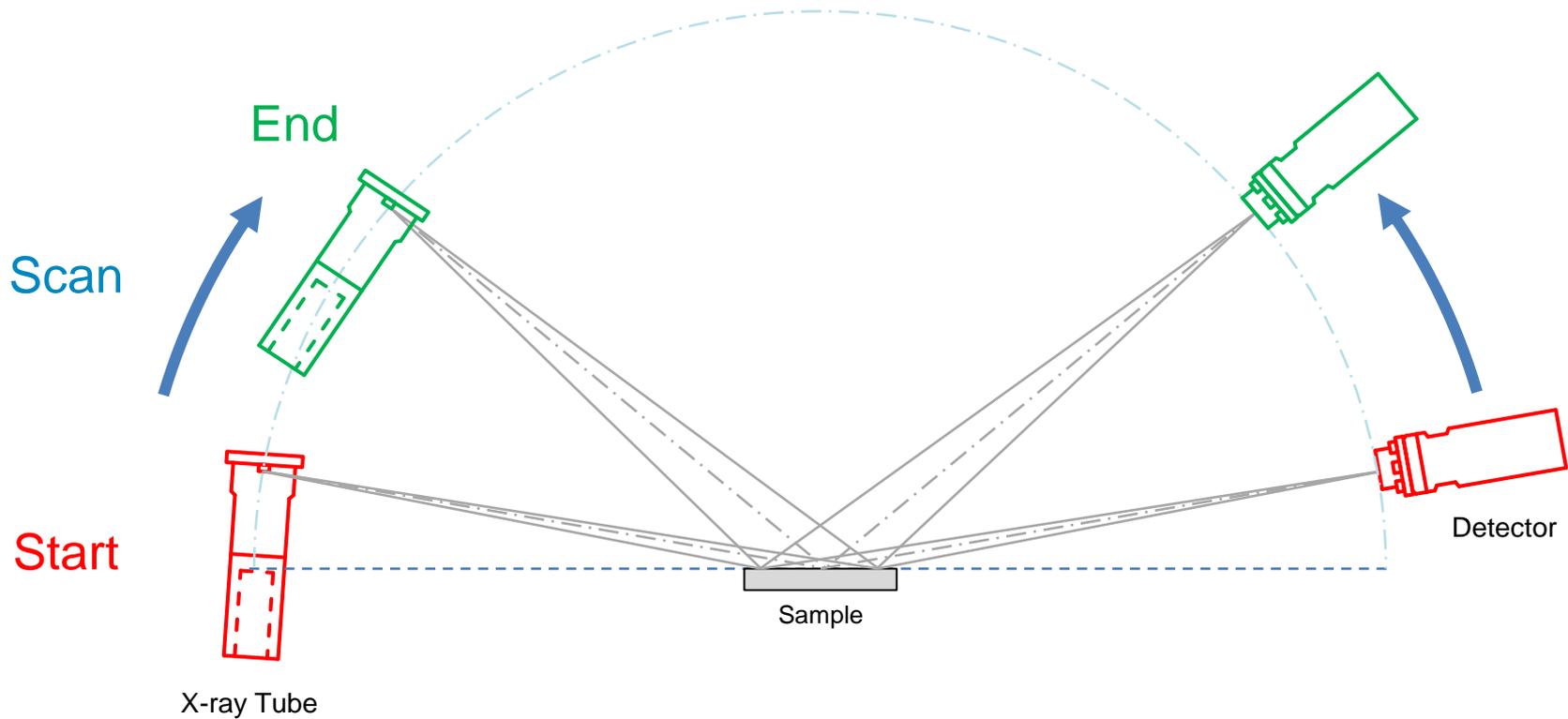
Reflective Geometry is ideal for:

- Absorbing materials (Ceramics, Metals)
- Thin films
- Texture analysis

Use characteristic radiation with high absorption coefficient

# Bragg-Brentano Parafocusing Diffractometer

Tube and Detector move symmetrically



# Instruments

Lab	Instrument	Monochromator	Configuration
RMS Foundation	Bruker D8	Energy dispersive Detector	Bragg-Brentano (Reflection) Debye-Scherrer (Capillary)
Uni Bern	Panalytical X'Pert	Ni-Filter	Bragg-Brentano (Reflection)
Uni Bern	Panalytical CubiX	Graphite Monochromator	Bragg-Brentano (Reflection)



Bruker D8

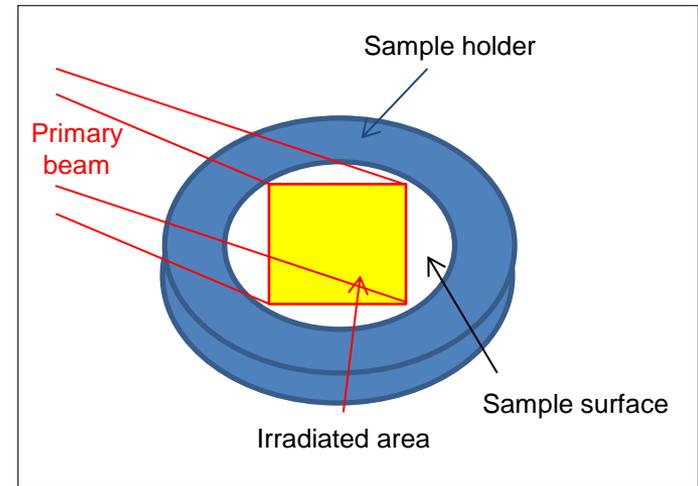
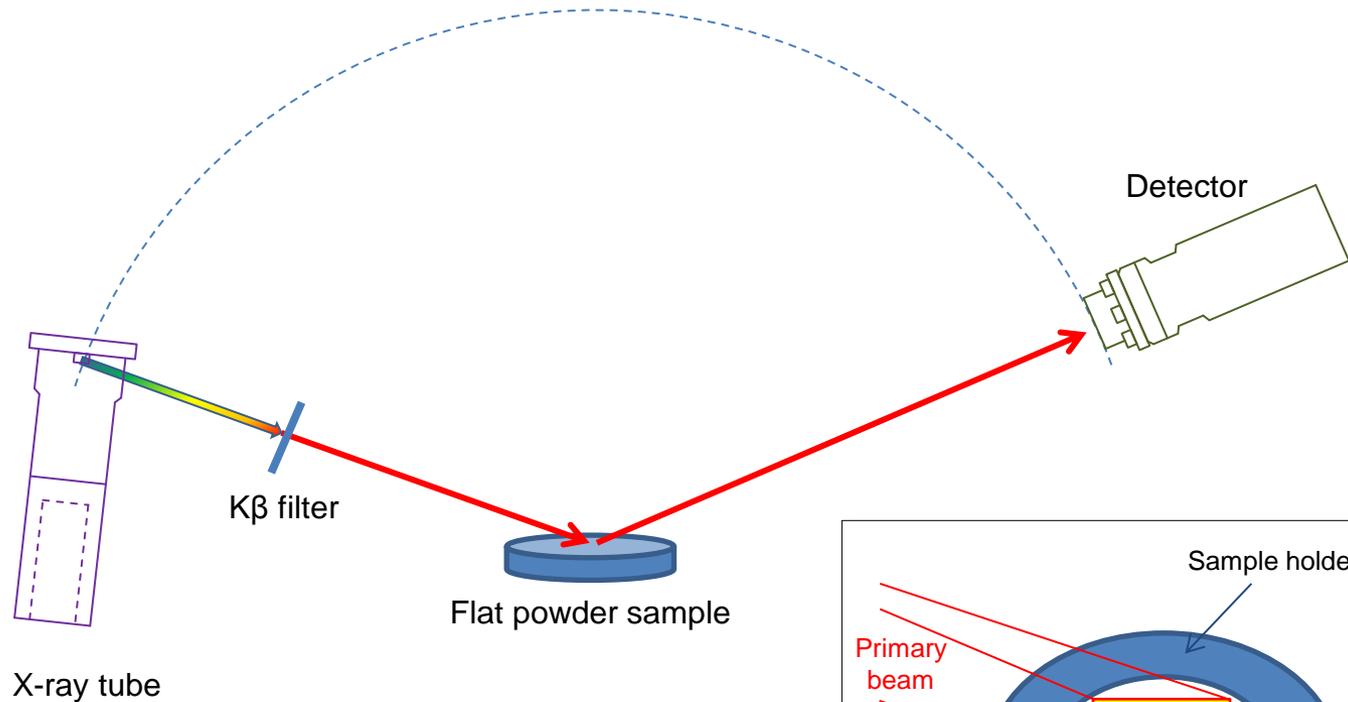


Panalytical X'Pert



Panalytical CubiX

# Bragg-Brentano Diffractometer

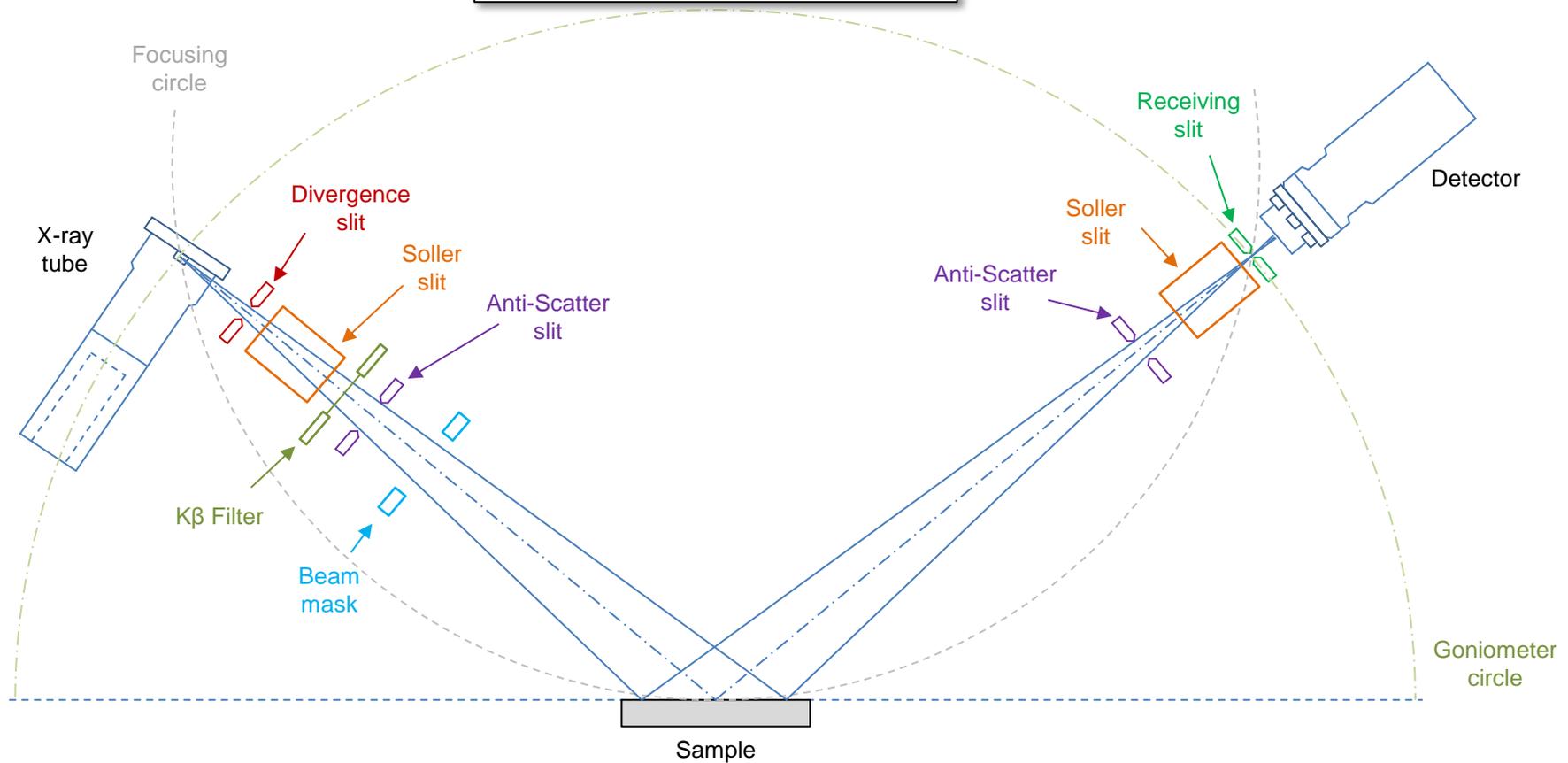


More optical elements are required to control the beam pattern.

# Bragg-Brentano Parafocusing Diffractometer

## Typical Configuration

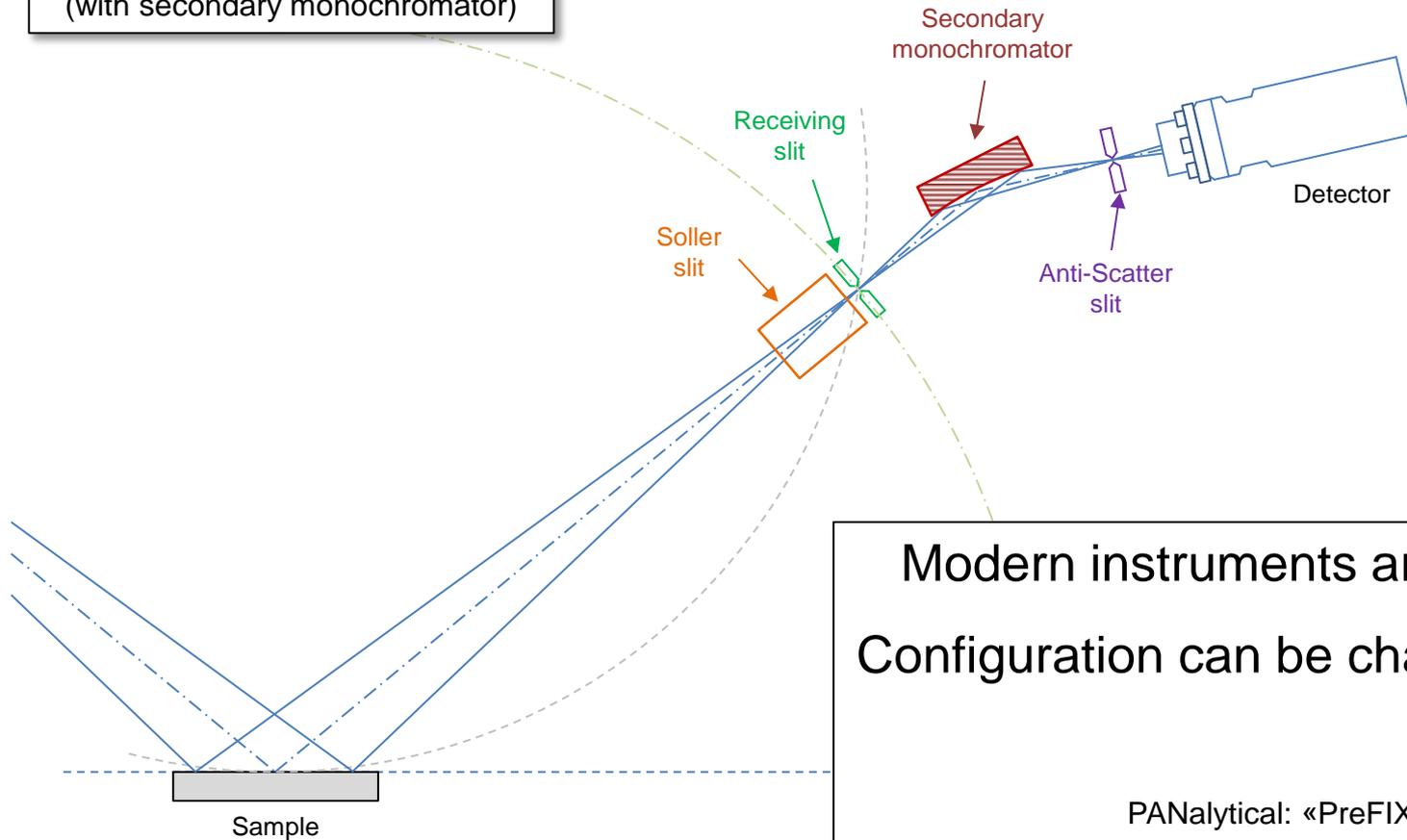
(with  $K\beta$  filter)



# Bragg-Brentano Parafocusing Diffractometer

## Typical Configuration

(with secondary monochromator)



Modern instruments are modular.  
Configuration can be changed easily.

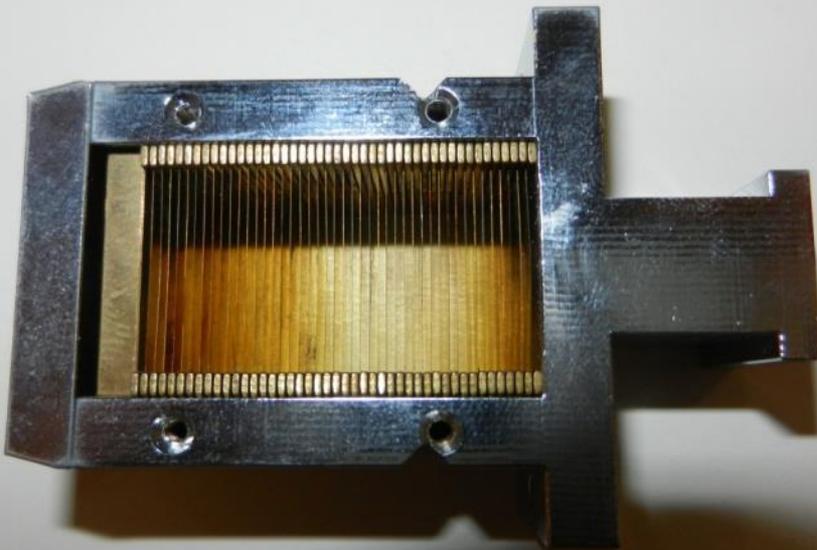
PANalytical: «PreFIX»

Bruker: «SNAP-LOCK»

# Beam Divergence



Divergence Slit



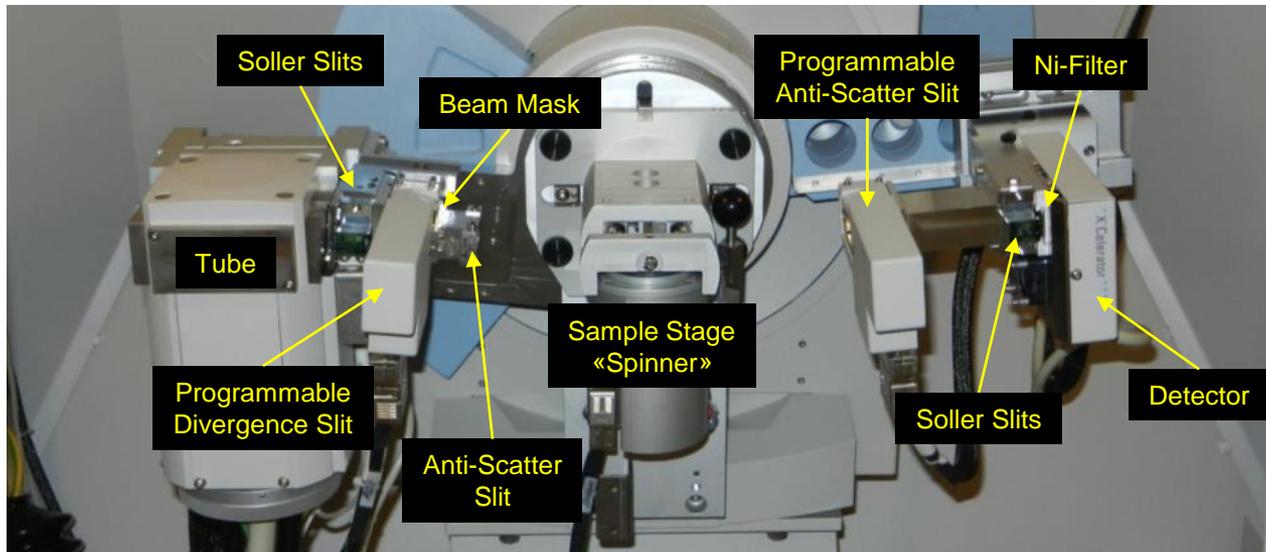
Soller Slit



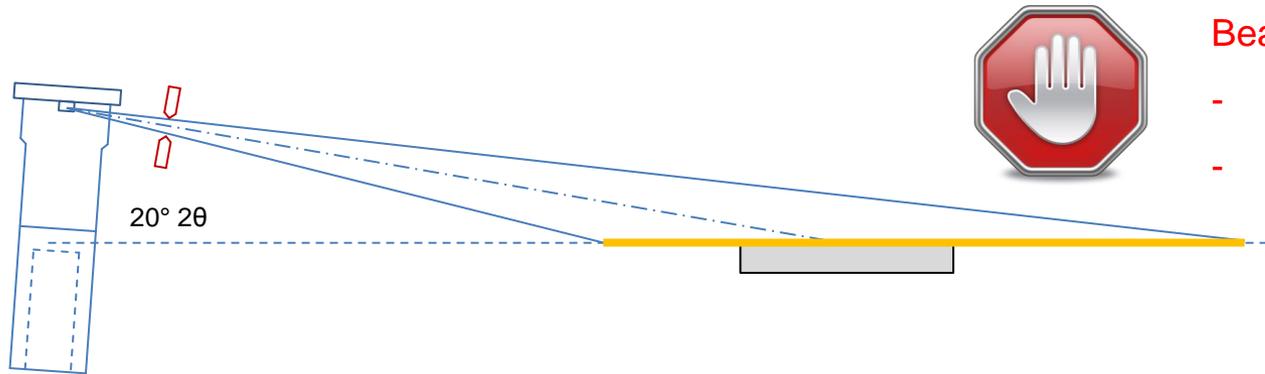
Beam Masks

# Instrument Configuration

- Many optical elements = many options to optimize data quality
- How to find the best configuration?

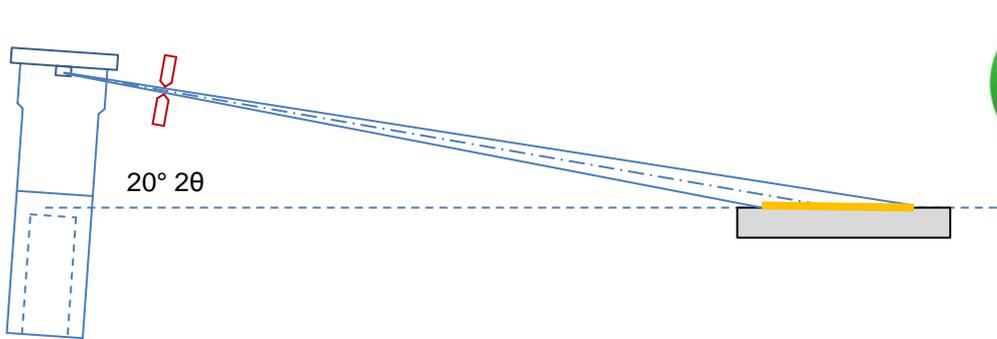


# Optimum Settings: Divergence Slit

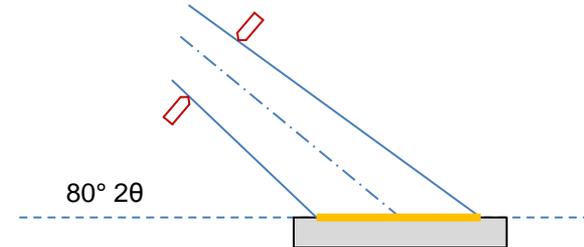
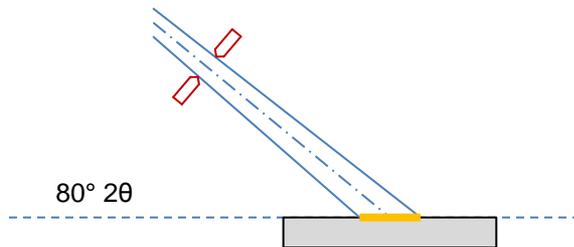


Beam overflow!

- Wrong peak intensities
- Artifact signal from sample holder

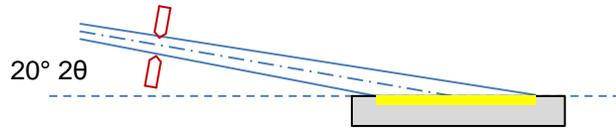


Reduced beam divergence angle



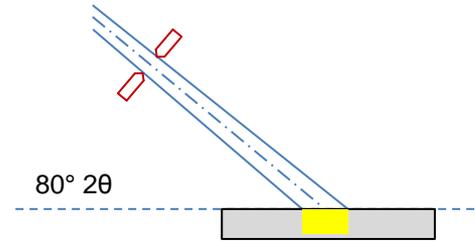
# Optimum Settings: Divergence Slit

## Fixed divergence slit:



Low incident angle:

- Low penetration depth
- Large illuminated area

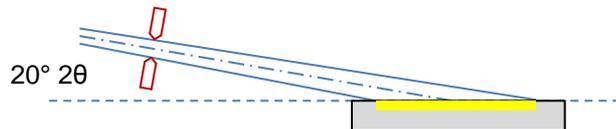


High incident angle:

- Deep penetration depth
- Small illuminated area

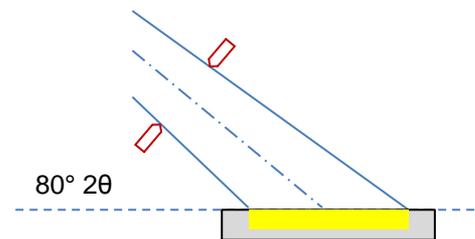
Irradiated **Volume**  
is constant  
Constant intensity of  
diffraction pattern

## Variable divergence slit:



Low incident angle:

- Narrow divergence slit
- Low penetration depth

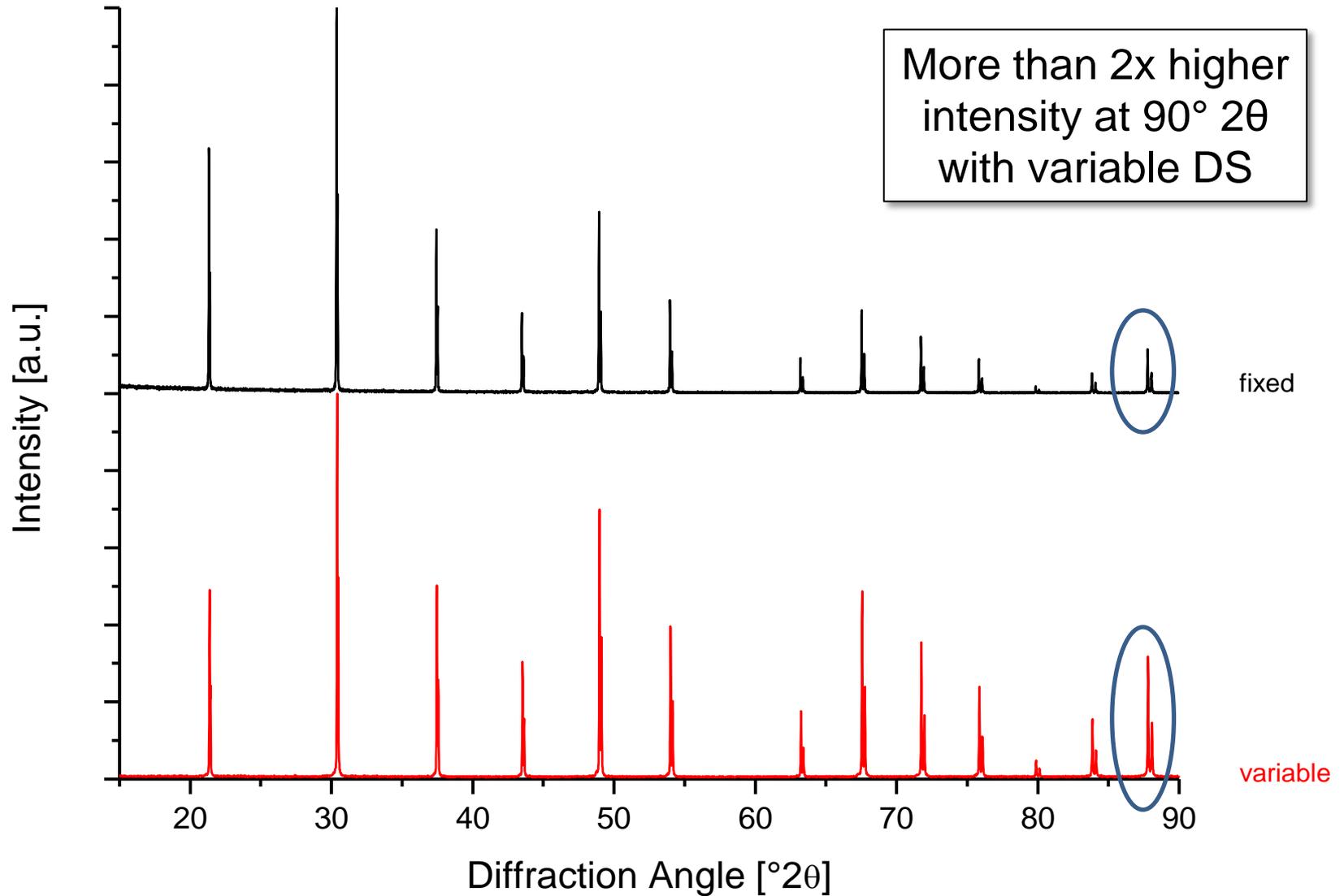


High incident angle:

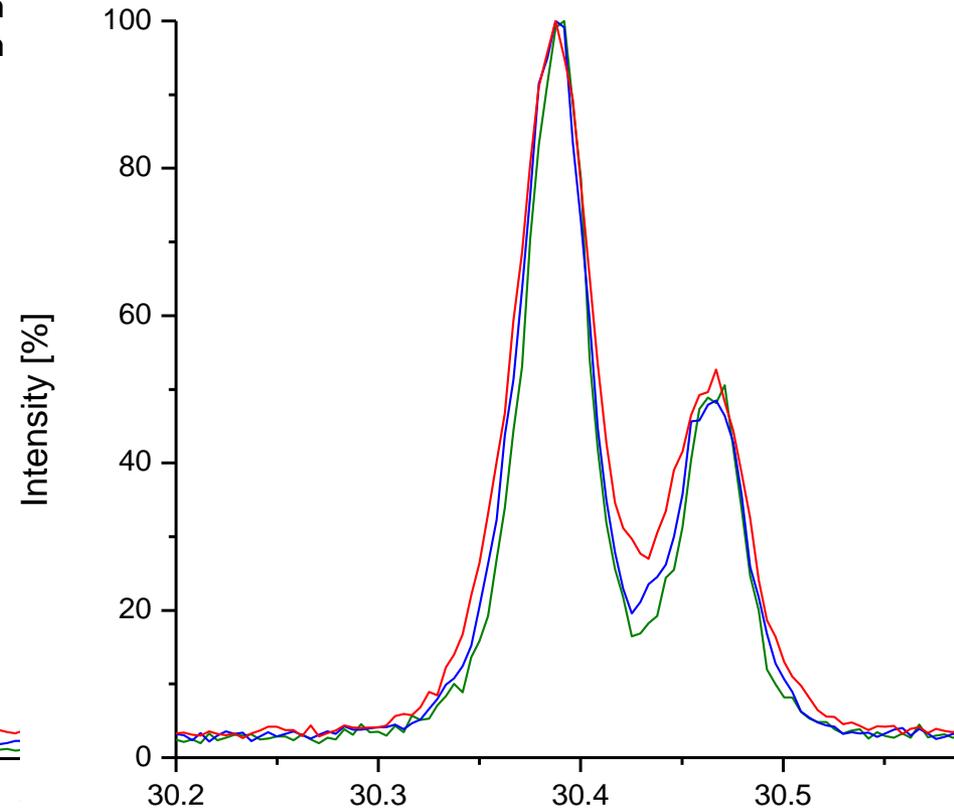
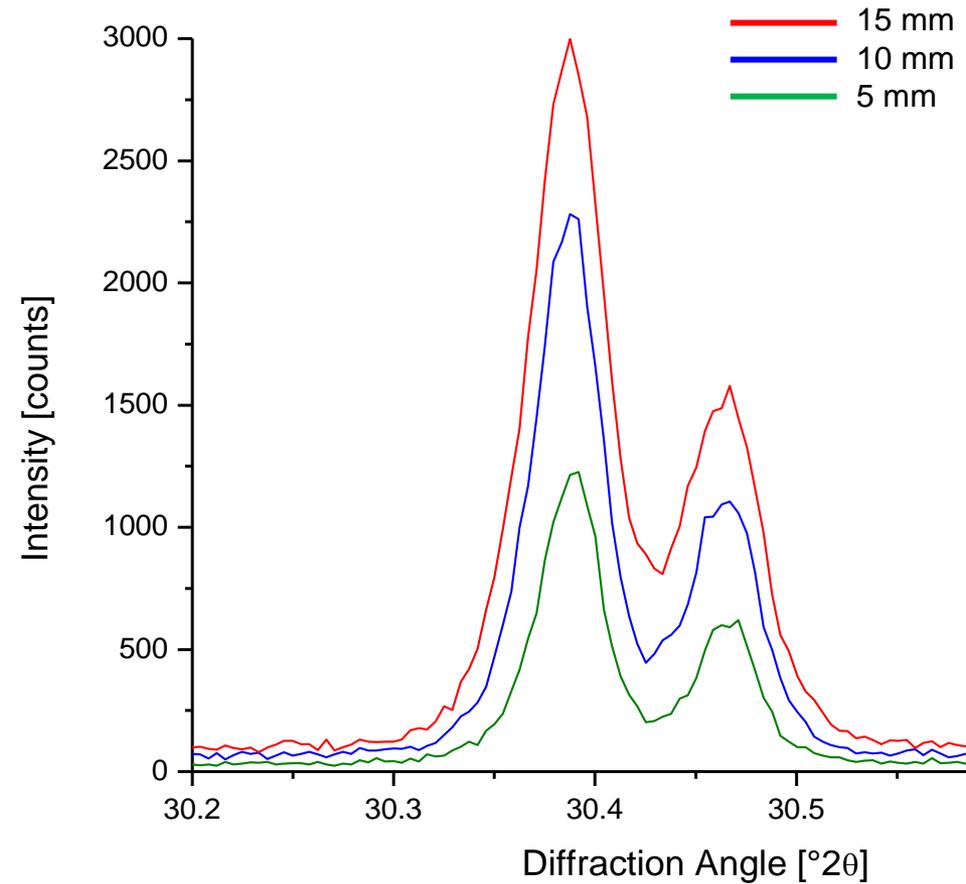
- Wide divergence slit
- Deep penetration depth

Irradiated **Area**  
is constant  
Higher diffracted intensity  
at high 2θ angle

# Fixed vs. Variable Divergence Slit



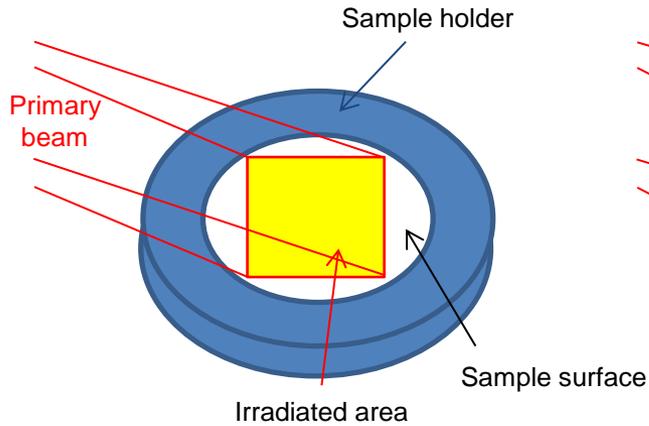
# Divergence Slit: Irradiated Length



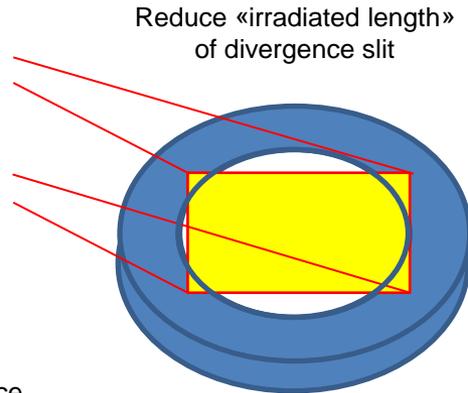
Soller Slits: 0.02 rad, Beam Mask: 10mm

# Optimum Settings: Divergence Slit

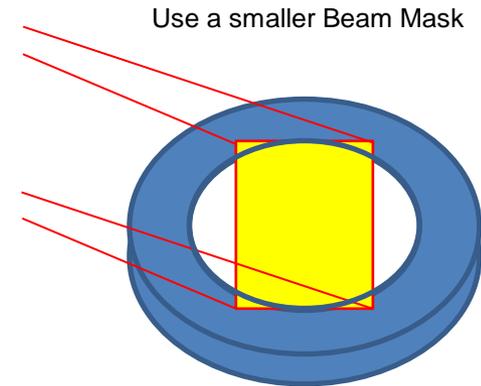
Correct!



Wrong!

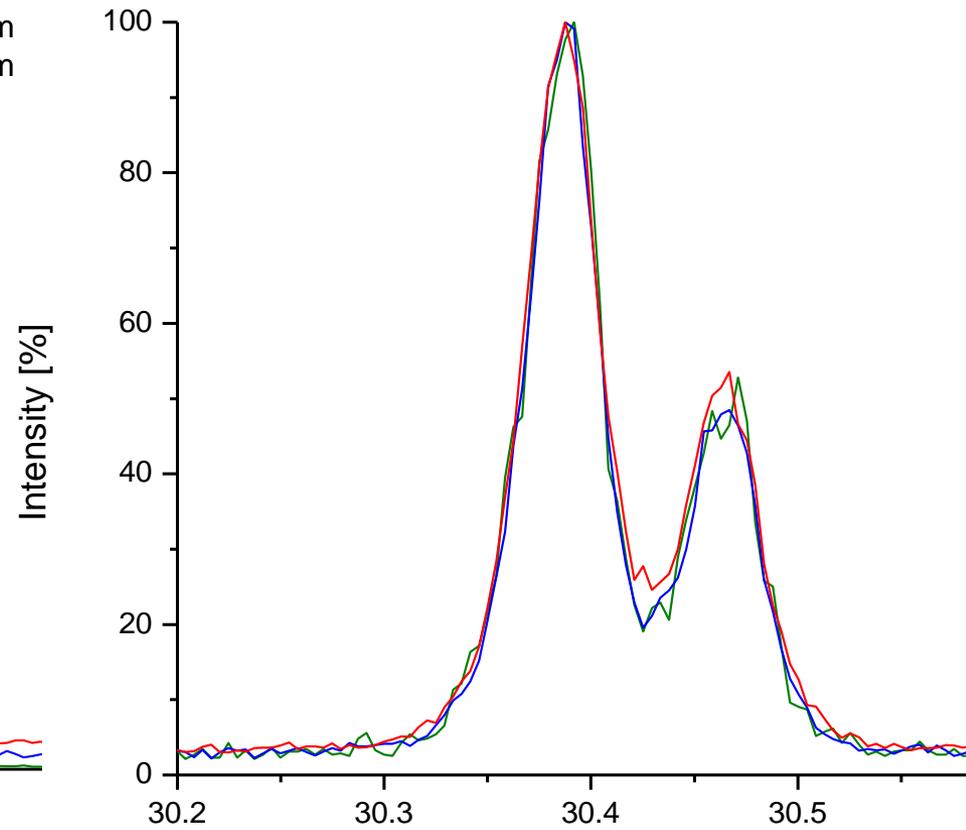
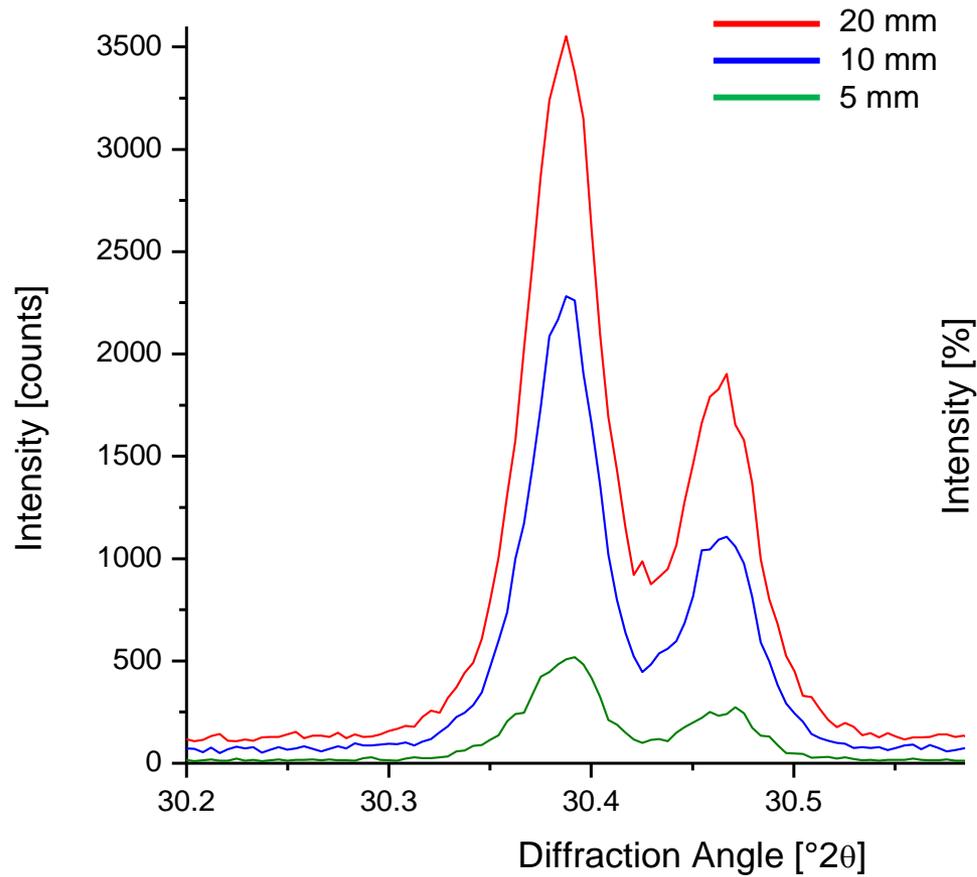


Wrong!



Beam Mask

# Beam Mask

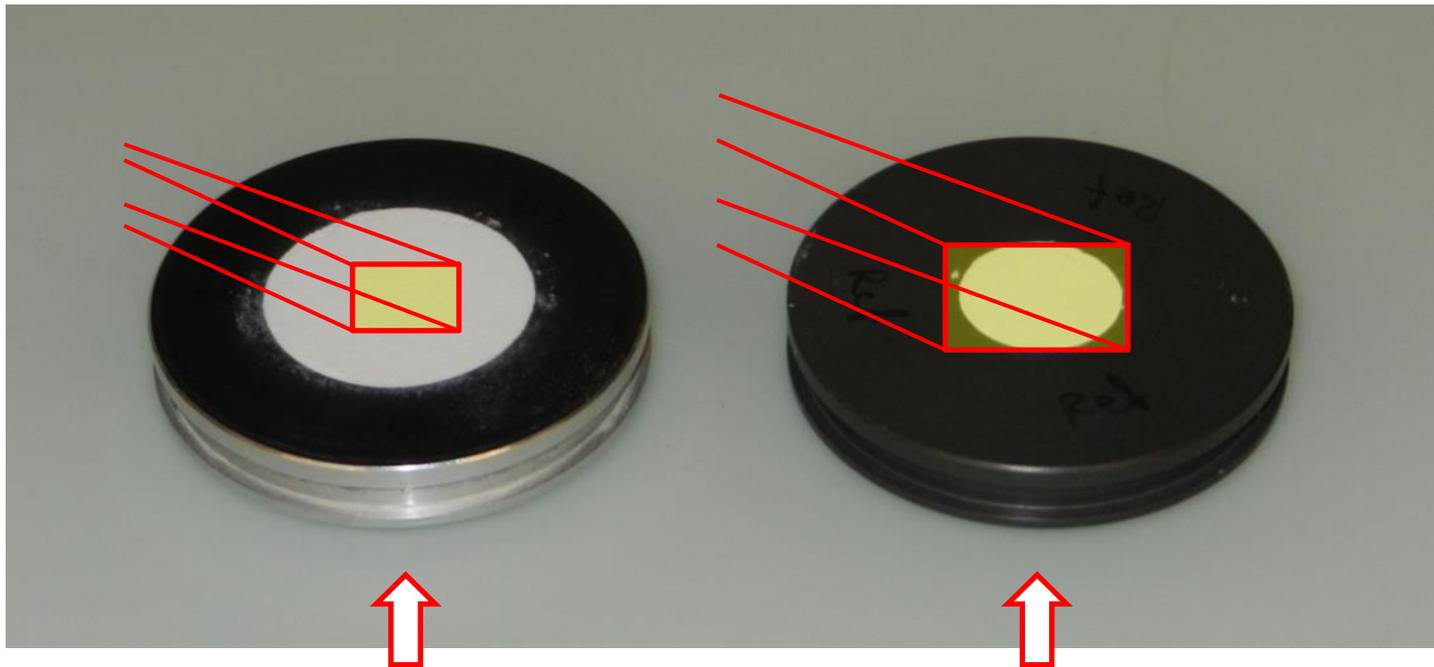


Soller Slits: 0.02 rad, Irradiated Length: 10mm

# Optimum Settings: Divergence Slit

Using sample holders of various sizes?

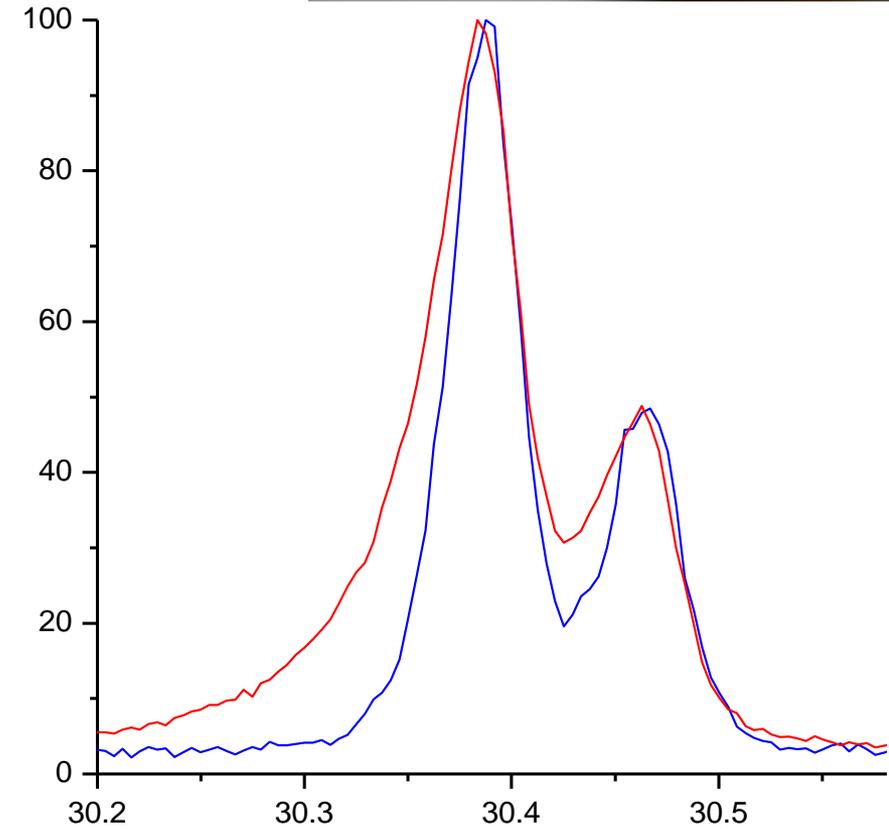
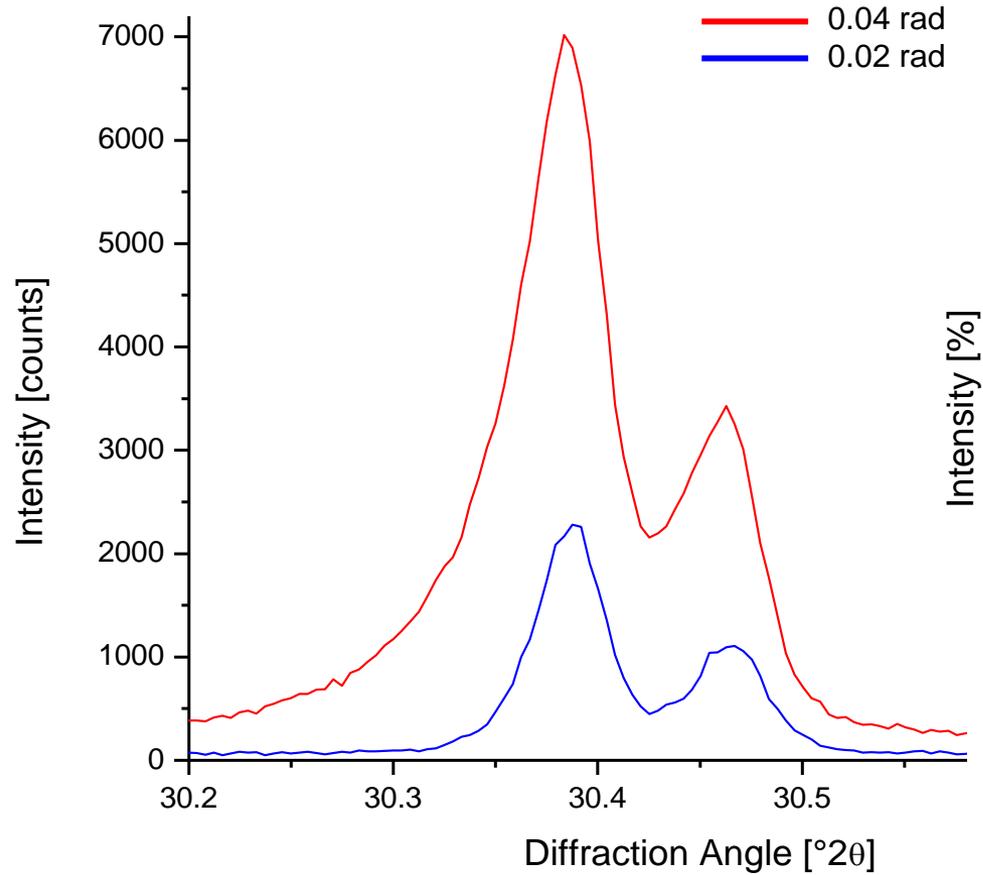
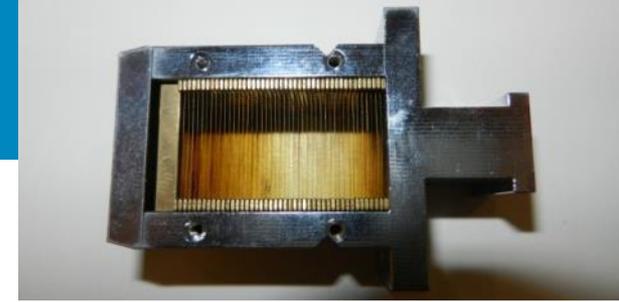
⇒ Match your Divergence Slit and Beam Mask!



Or else: Waste of intensity

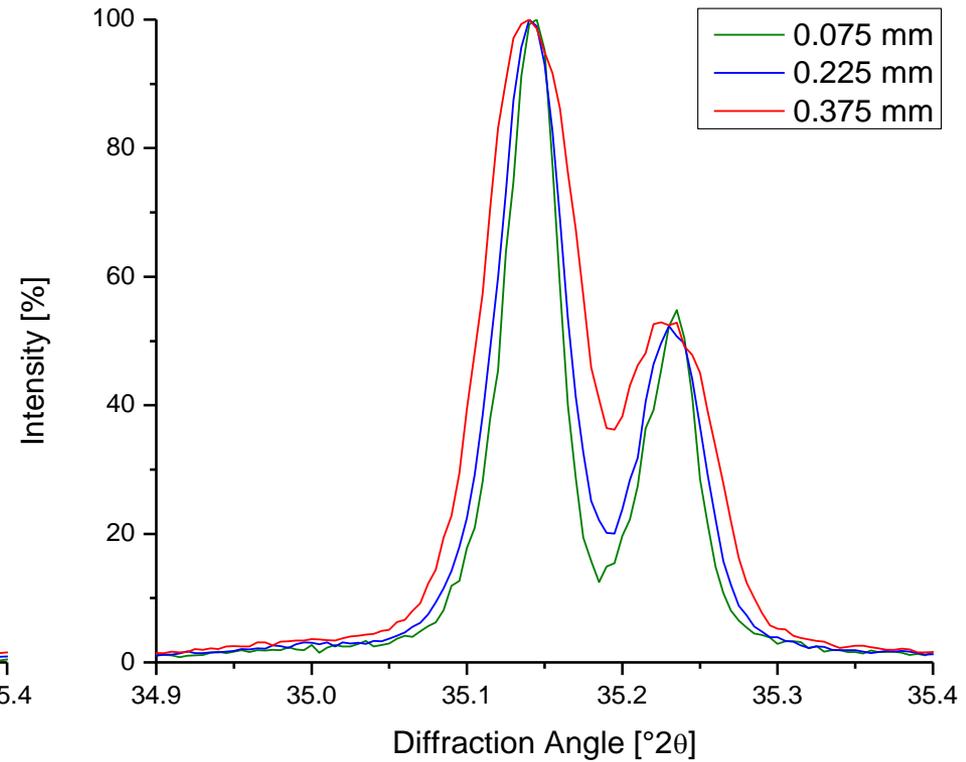
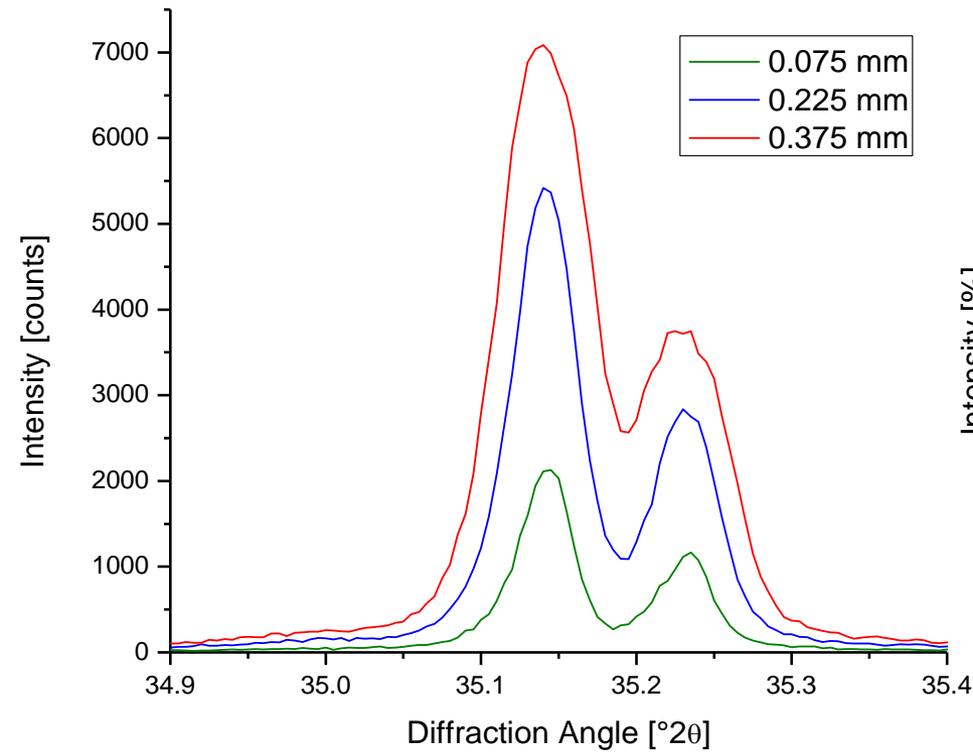
or Beam spill-over

# Soller Slits / Collimators



In primary & secondary beam, Beam Mask: 10mm, Irradiated Length: 10mm

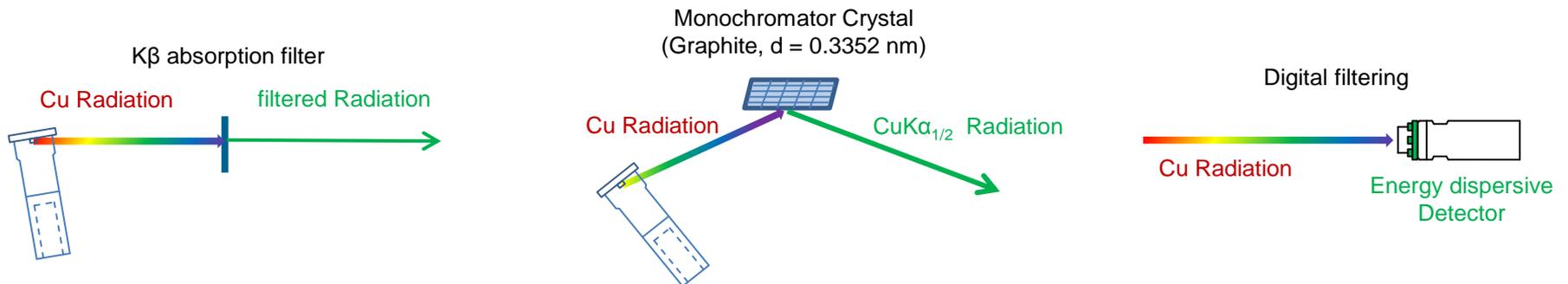
# Receiving Slit / Detector Slit



$\text{Al}_2\text{O}_3$ , 15 mm irradiated length, 2.5 $^{\circ}$  soller slit

# Summary: Monochromators

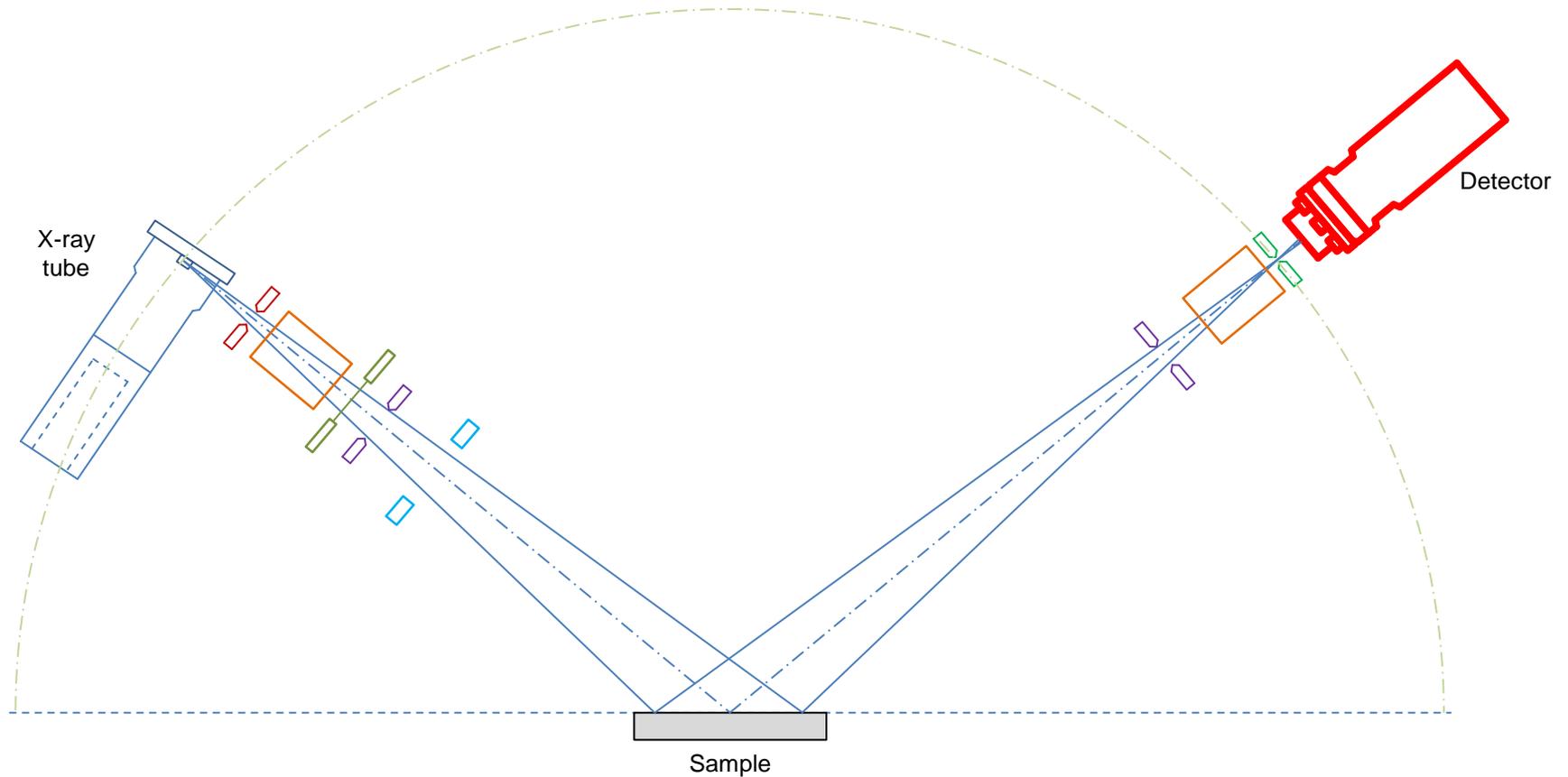
Optical Element	Effect on Spectrum	Effect on Intensity
K $\beta$ Filter	Reduces K $\beta$ peaks	Moderate loss
Graphite Monochromator	Eliminates K $\beta$ peaks Eliminates Fluorescence	Strong loss
Multi-bounce Monochromator	Eliminates K $\beta$ and K $\alpha_2$ Eliminates Fluorescence	Massive loss (mostly used on Synchrotrons)
Energy dispersive Detector	Reduces K $\beta$ peaks Eliminates Fluorescence	No loss



# Summary: Optical Elements

Optical Element	Effect	Too Small	Too Large
Divergence Slit	Adjusts beam length on the sample	Loss of intensity	Beam spills over sample
Soller Slit	Reduces peak asymmetry	Loss of intensity, Better resolution	More asymmetry, Less resolution
Anti-Scatter Slit	Reduces background signal	Loss of intensity	High background
Beam Mask	Adjusts beam width on the sample	Loss of intensity	Beam spills over sample
<del>Receiving Slit</del>	<del>Adjusts peak width / resolution</del>	<del>Loss of intensity Better resolution</del>	<del>Loss of resolution Higher intensity</del>
K $\beta$ Filter	Reduces K $\beta$ peaks	-	-
Graphite Monochromator	Eliminates K $\beta$ peaks	-	-

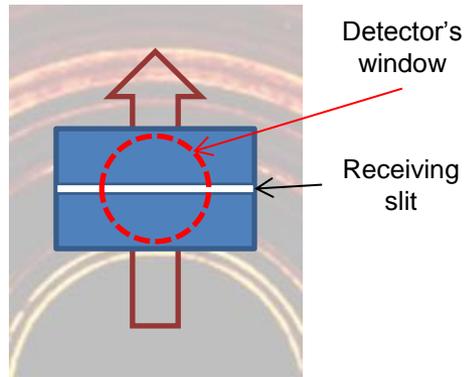
# Bragg-Brentano Parafocusing Diffractometer



# Detectors

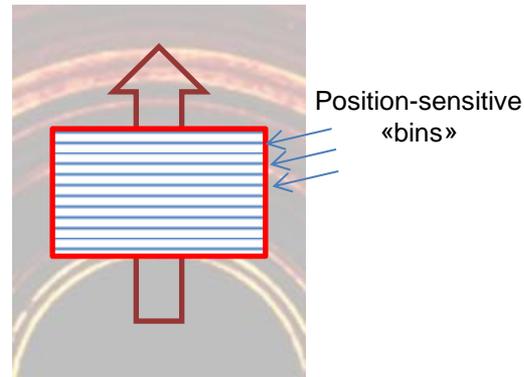
Detector Type

Point Detector (0D)



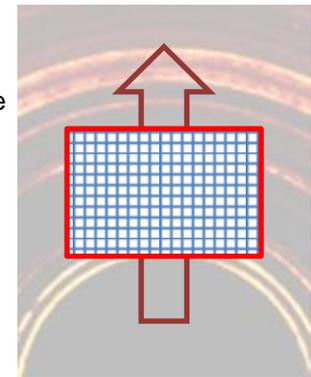
Receiving slit determines active height

Linear Detector (1D)



Linear array of solid state detectors

Area Detector (2D)



2D array of solid state detectors

Example

Scintillation counter (various)  
SOL-XE (Bruker)  
XFlash (Bruker)

X'Celerator (PANalytical)  
PIXcel<sup>1D</sup> (PANalytical)  
LynxEye (Bruker)  
LynxEye XE (Bruker)  
Vântec-1 (Bruker)  
D/teX Ultra (Rigaku)

PIXcel<sup>3D</sup> (PANalytical)  
Vântec-500 (Bruker)

Key Features

SOL-XE:  
Energy dispersive  
  
XFlash:  
Combines XRD + XRF

Fast  
  
LynxEye XE:  
Energy dispersive

Fast  
  
2D image of  
Debye rings

# Instruments

Lab	Instrument	Monochr.	Detector
RMS Foundation	Bruker D8	Energy dispersive Detector	1D LynxEye XE
Uni Bern	Panalytical X'Pert	Ni-Filter	1D X'Celerator
Uni Bern	Panalytical CubiX	Graphite	0D Scintillation Counter



Bruker D8



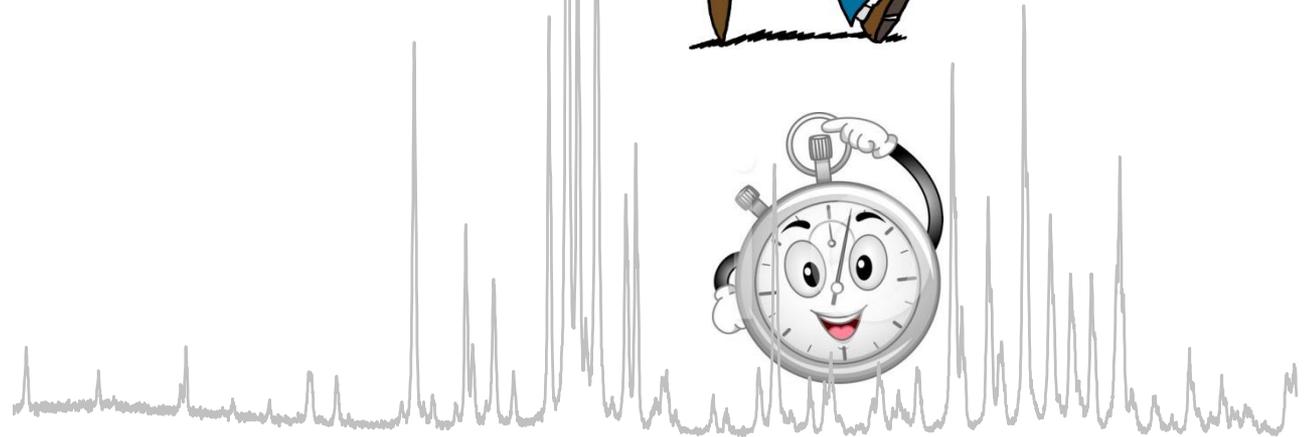
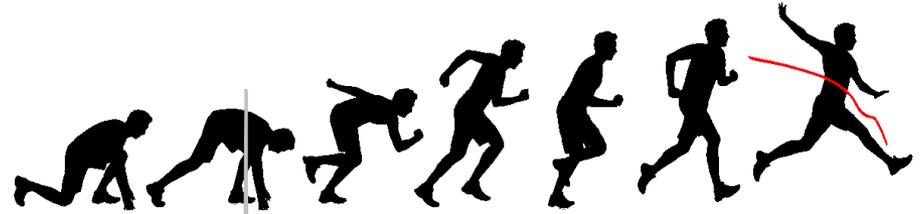
Panalytical X'Pert



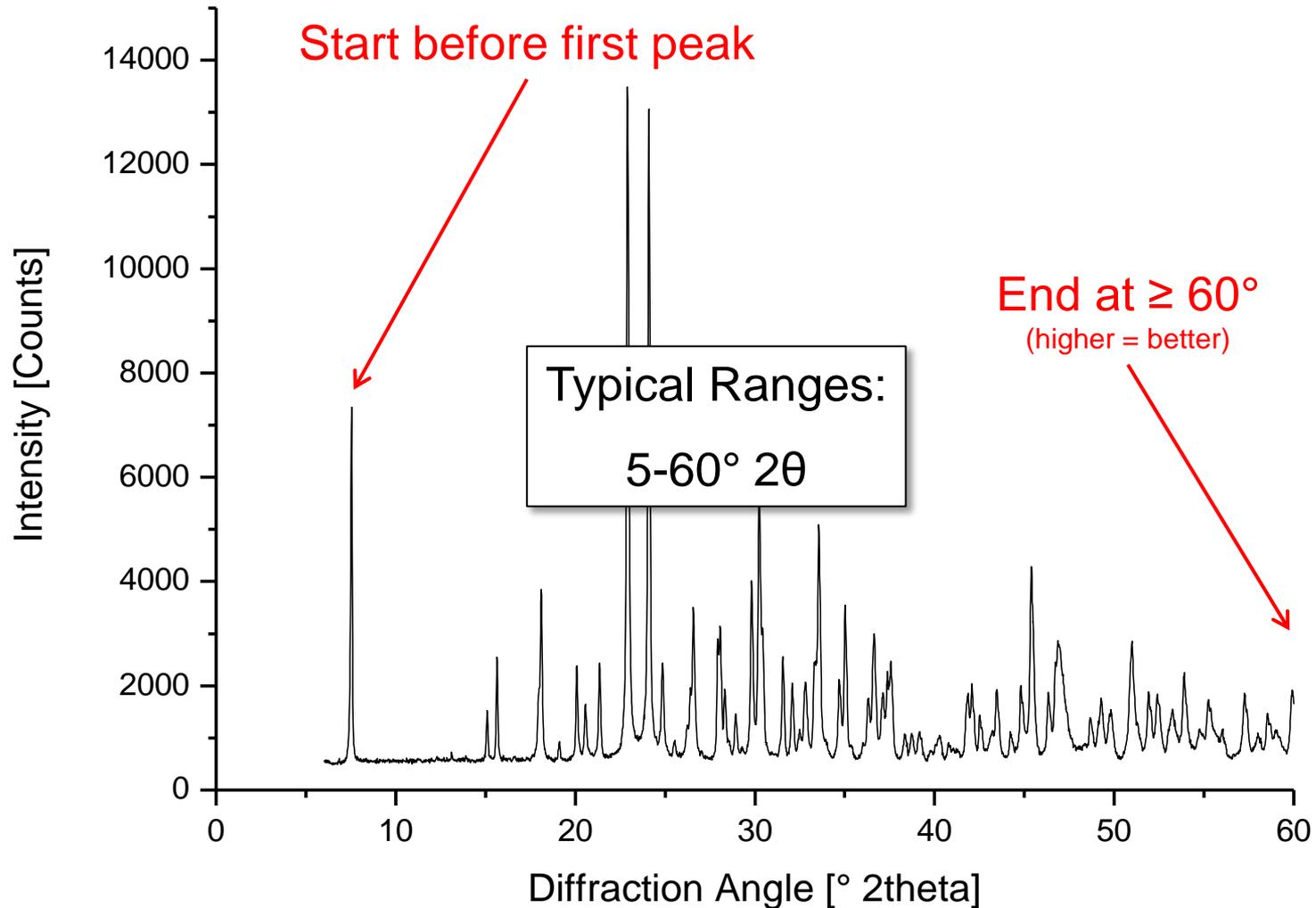
Panalytical CubiX

# Measurement parameters

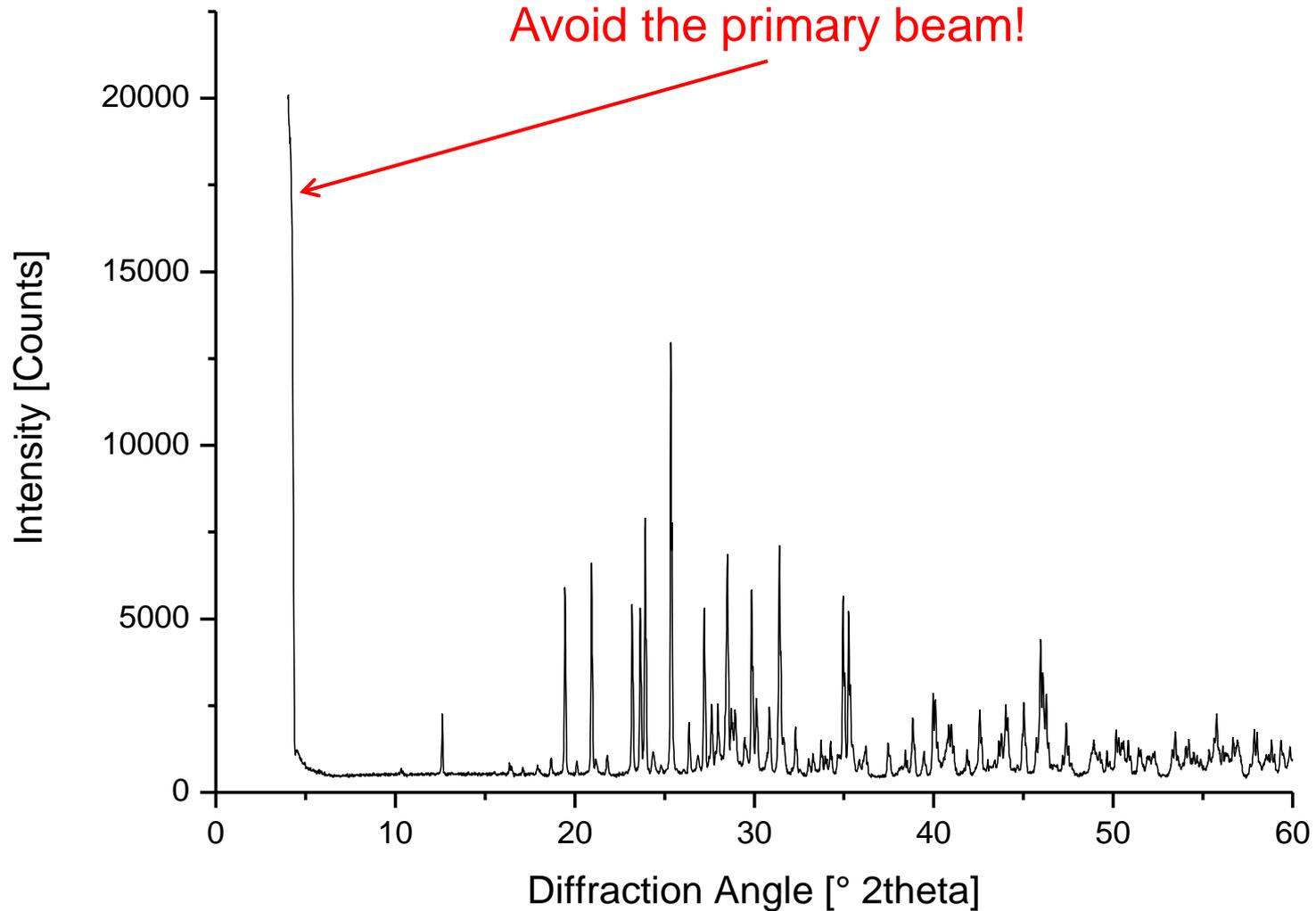
- Angular Range
- Step Size
- Counting Time



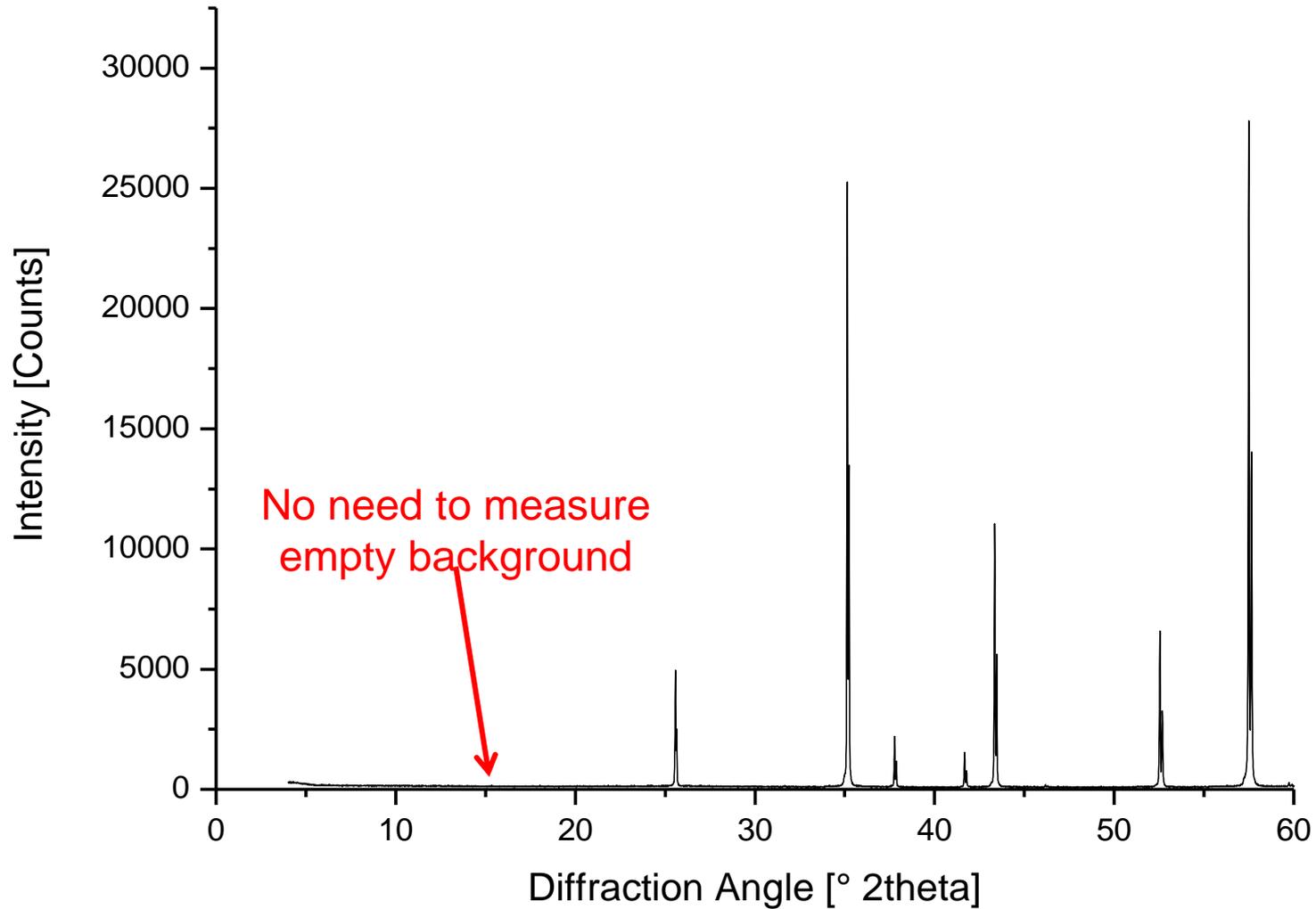
# Angular Range



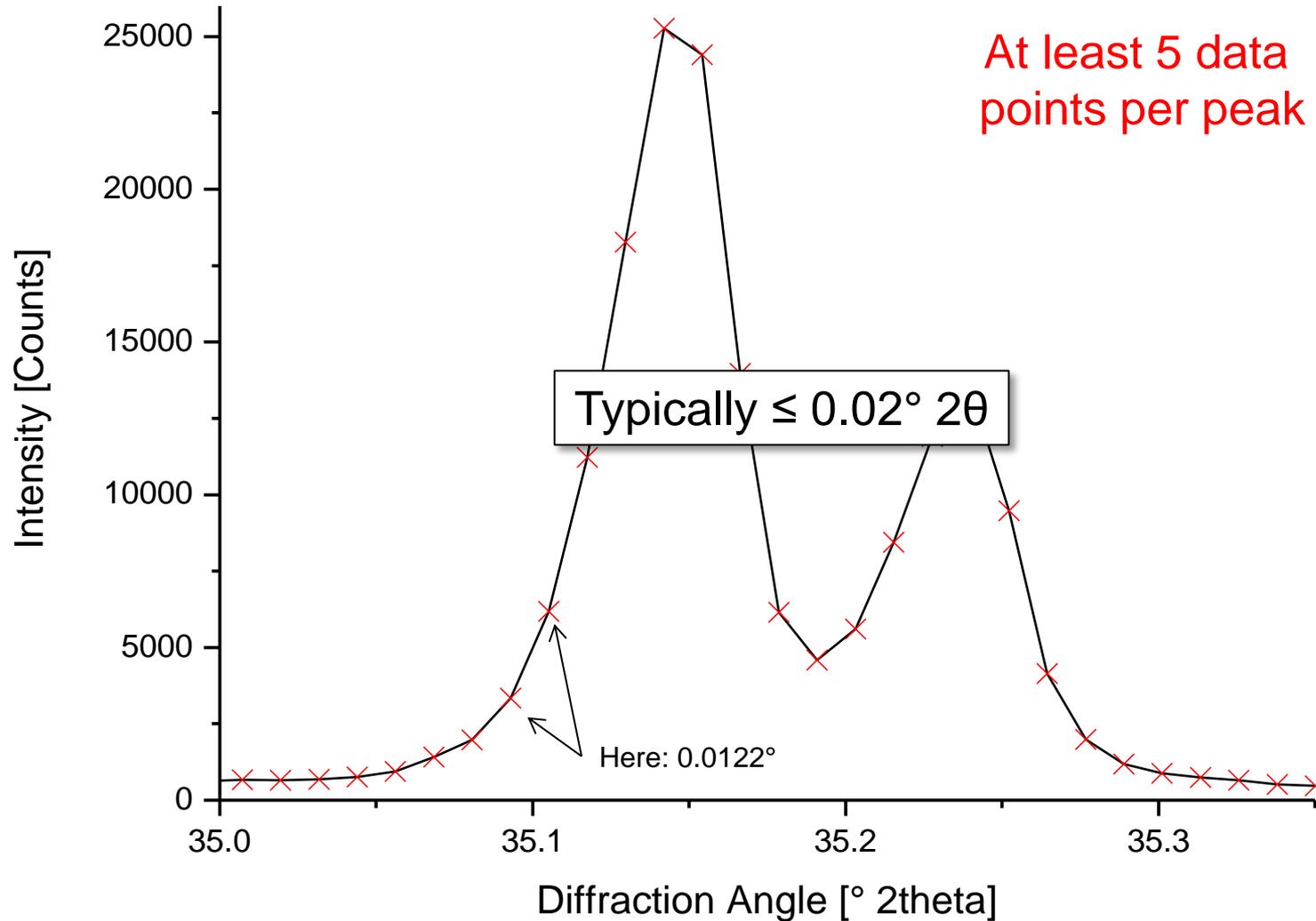
# Angular Range



# Angular Range

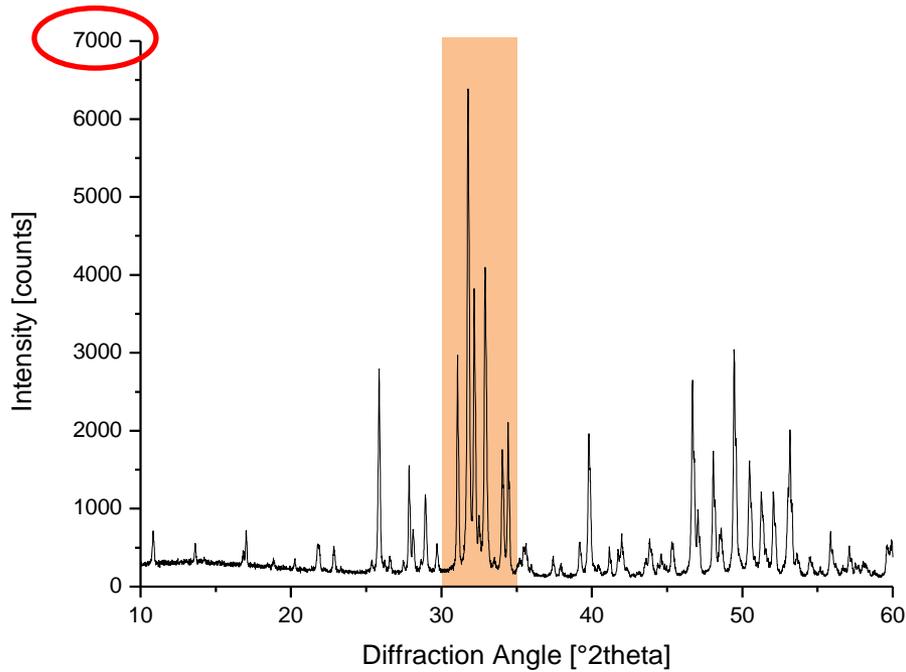


# Step Size



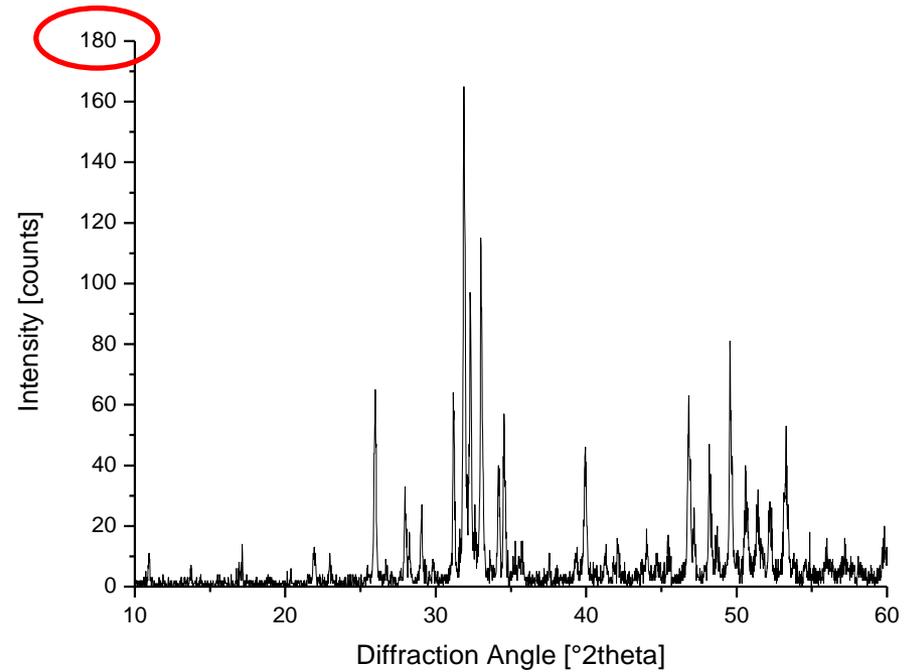
# Time per Step

## 1D Energy dispersive Detector



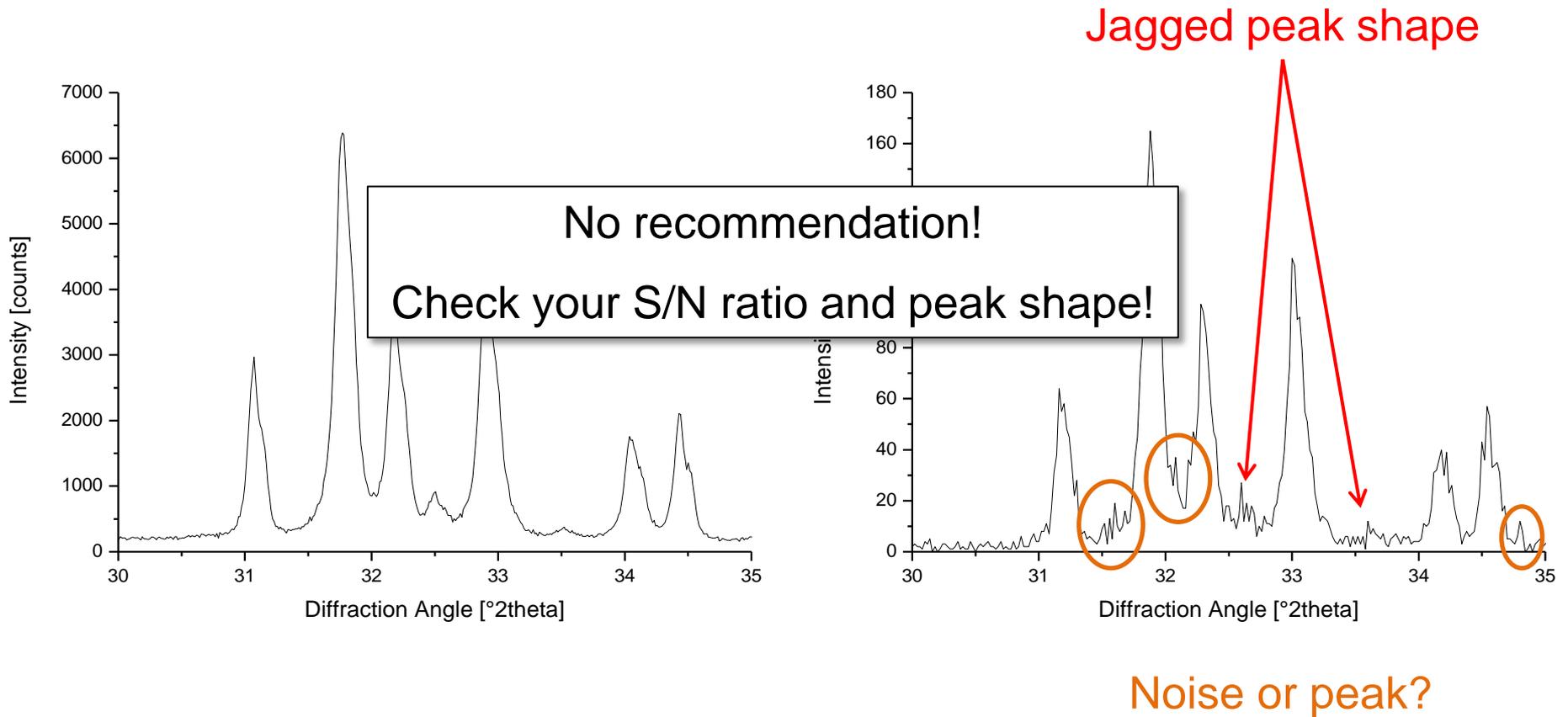
12.5 min

## 0D Detector



12.5 min

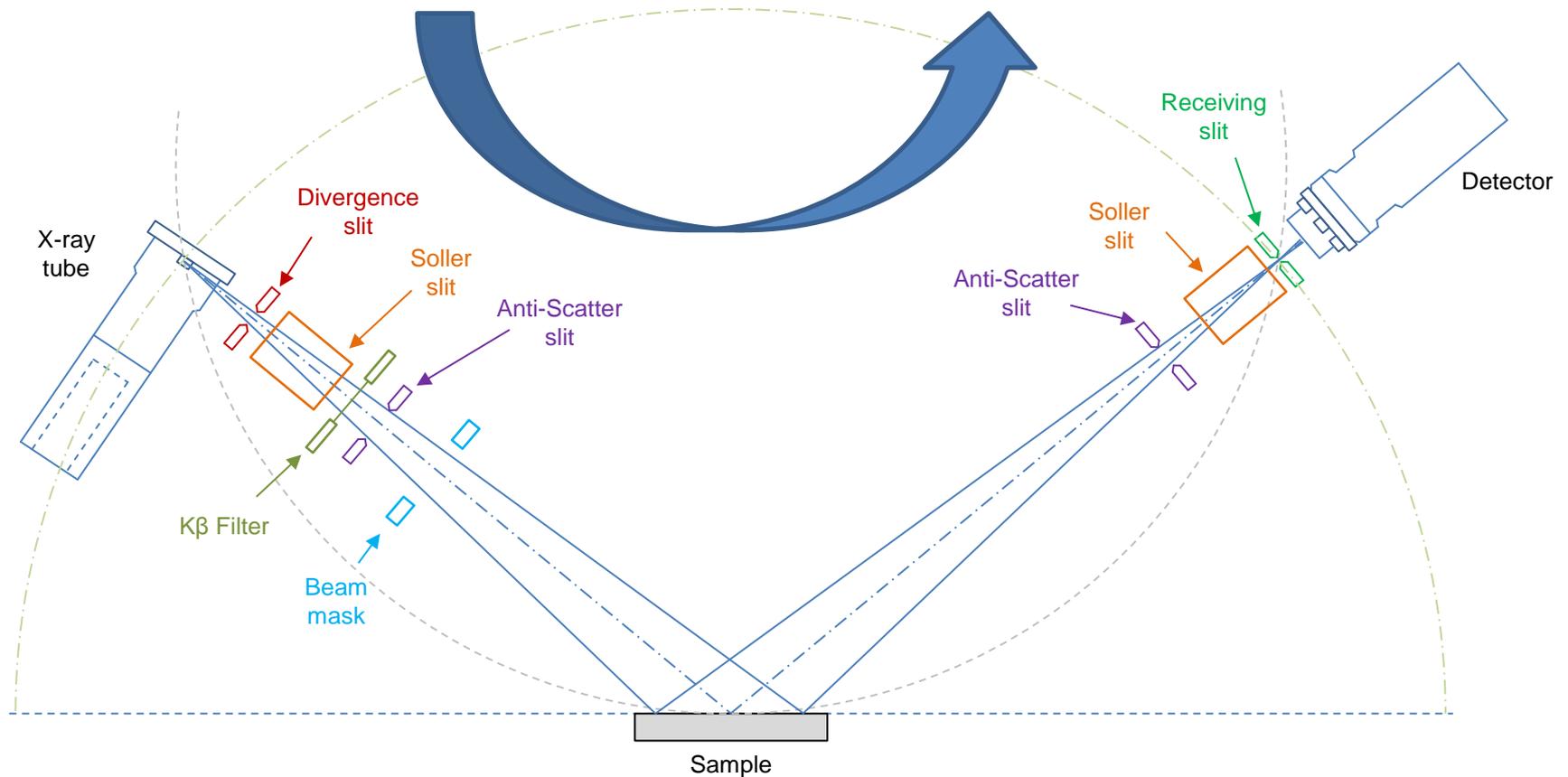
# Examples



Noise or peak?

# Data Quality Checklist

Check beam paths Tube → Sample → Detector



# Data Quality Checklist

For linear detector with  $K\beta$  filter

	Optical Element	Ideal setup
Incident beam path	 Divergence Slit	Automatic Max irr. length w/o beam overflow
	 Soller Slit	Installed Small opening
	 Mask	Installed (if available) Max irr. width w/o beam overflow
	 Anti-scatter slit	Identical to divergence slit
Diffracted beam path	 Sample	Spinning
	 Anti-scatter slit	Wide open
	 Soller slit	Installed Small opening
	 Additional slits	Wide open
	 $K\beta$ filter	Installed